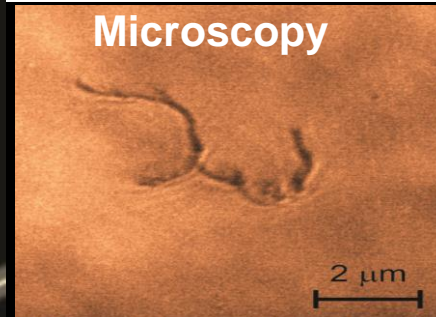


**Jorge J. Rocca, B. Reagan, Y. Wang,
D. Alessi, B. Luther, K. Wernsing, L. Yin,
M. Curtis, M. Berrill, D. Martz, V. Shlyaptsev,
S. Wang, F. Furch, M. Woolstron, D. Patel,
M.C. Marconi, C.S. Menoni**

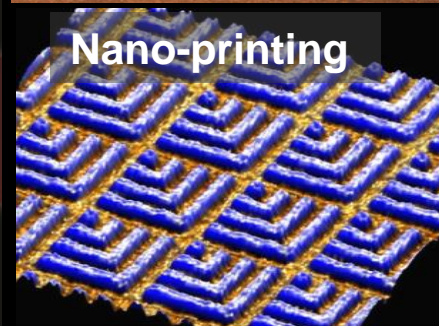
**NSF Engineering Research Center for
Extreme Ultraviolet Science & Technology
Colorado State University**

**Work Supported by the NSF Engineering Research Centers
Program and the US Department of Energy**

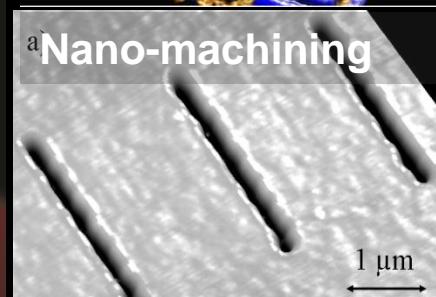
Microscopy



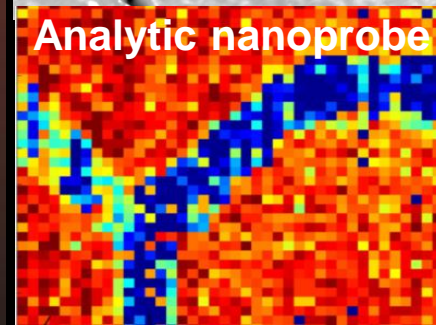
Nano-printing

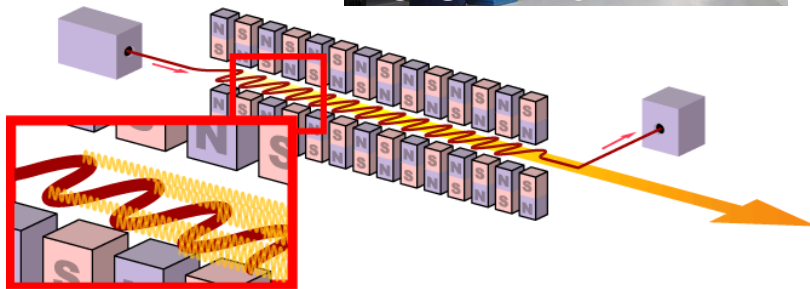
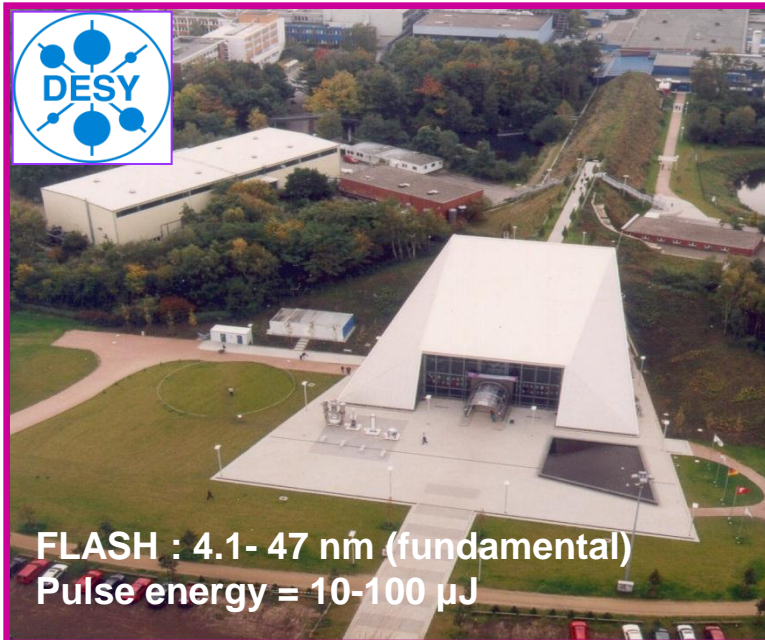


a Nano-machining

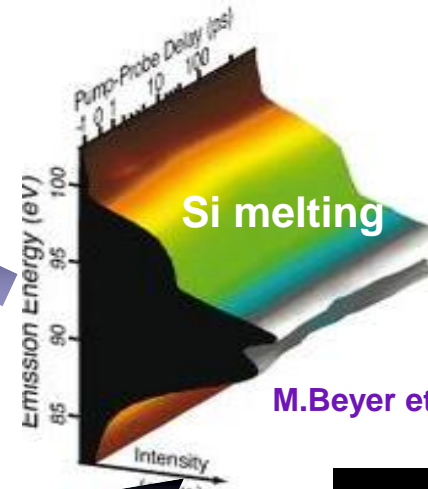


Analytic nanoprobe

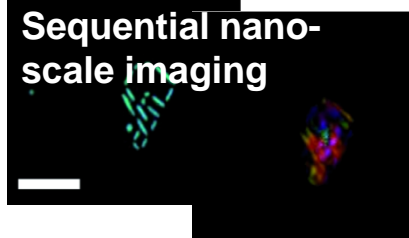




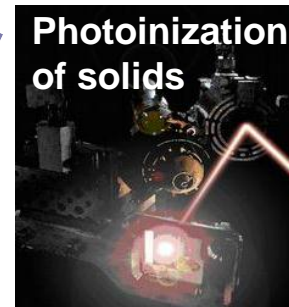
<http://en.wikipedia.org/wiki/File:FEL.png>



M.Beyer et al. PNAC, (2010)



A. Barty et al. Nat. Phot., (2008)



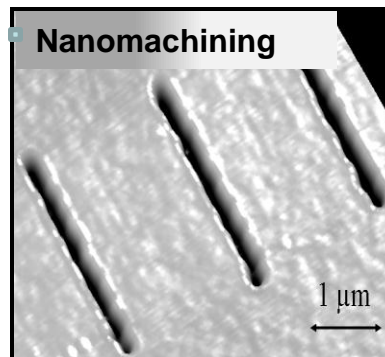
Nagler et al. Nat. Phys. (2011)

Compact plasma-based soft x-ray lasers can be installed at the application's site

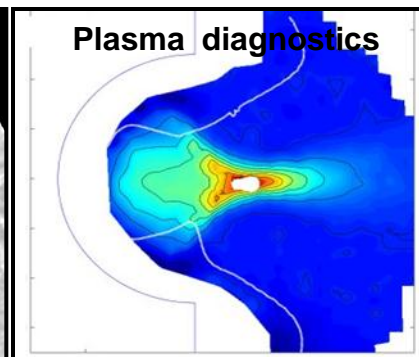
Discharge Pumped SXRL
 $\lambda = 46.9 \text{ nm}$



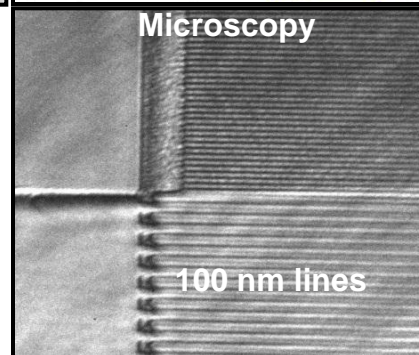
Nanomachining



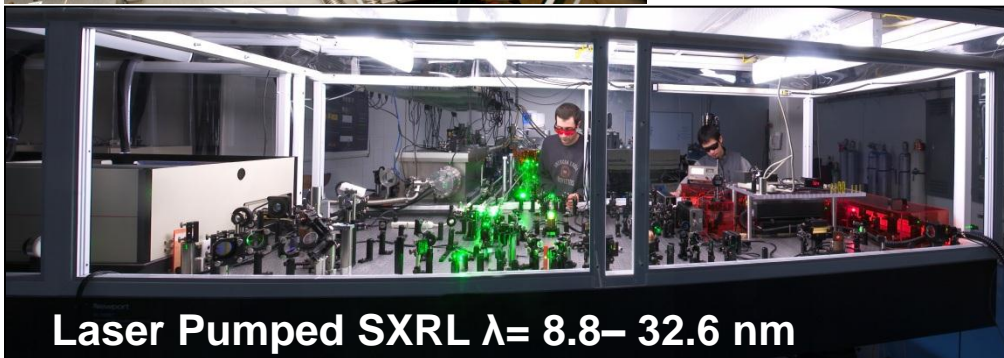
Plasma diagnostics



Microscopy

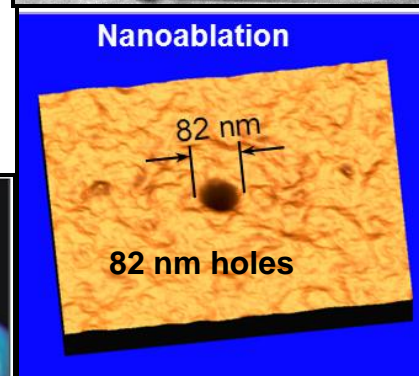


Laser Pumped SXRL $\lambda = 8.8 - 32.6 \text{ nm}$

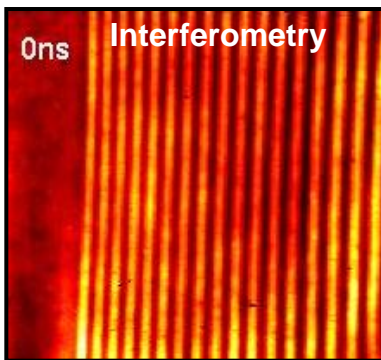


- High pulse energy (μJ -mJ)
- High monochromaticity ($\lambda/\Delta\lambda < 10^{-4}$)
- High peak spectral brightness

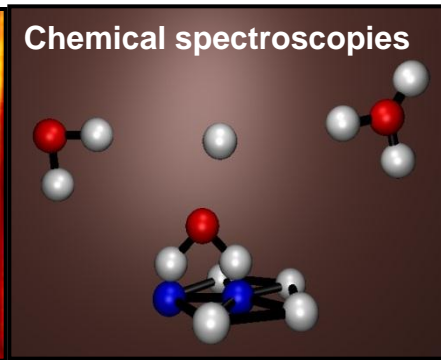
Nanoablation



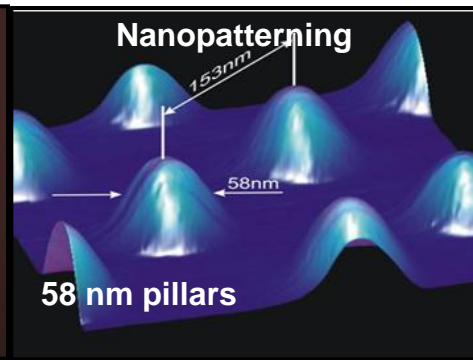
0ns Interferometry



Chemical spectroscopies

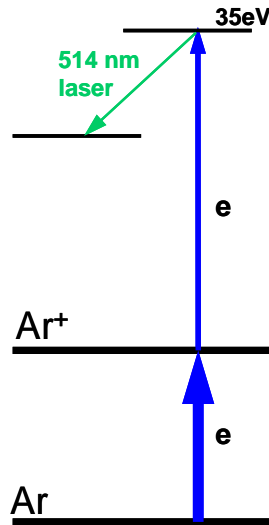


Nanopatterning



Soft x-ray lasers can be created by electron impact excitation of highly ionized atoms in dense plasmas

Singly ionized Ar ion, Kr ion lasers in the visible spectral region

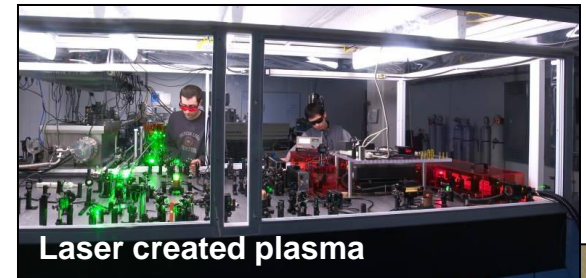


Plasma requirements:
 $T_e \sim 5 \text{ eV}$
 $N_e \sim 1 \cdot 10^{14} \text{ cm}^{-3}$

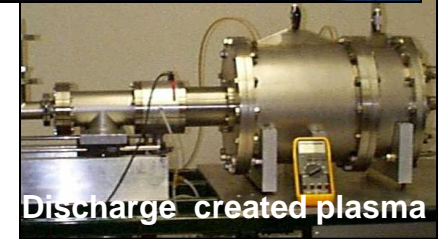
NexTe increases by 10^7 - 10^{10}

$T_e \sim 100\text{-}1000 \text{ eV}$
 $N_e \sim 1 \cdot 10^{19} - 1 \cdot 10^{21} \text{ cm}^{-3}$

Highly ionized (8-35 times) in the EUV/SXR spectral region

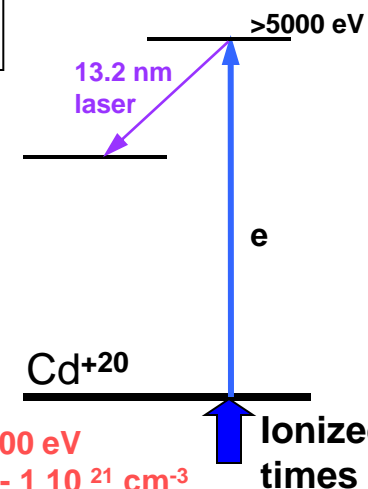


Laser created plasma



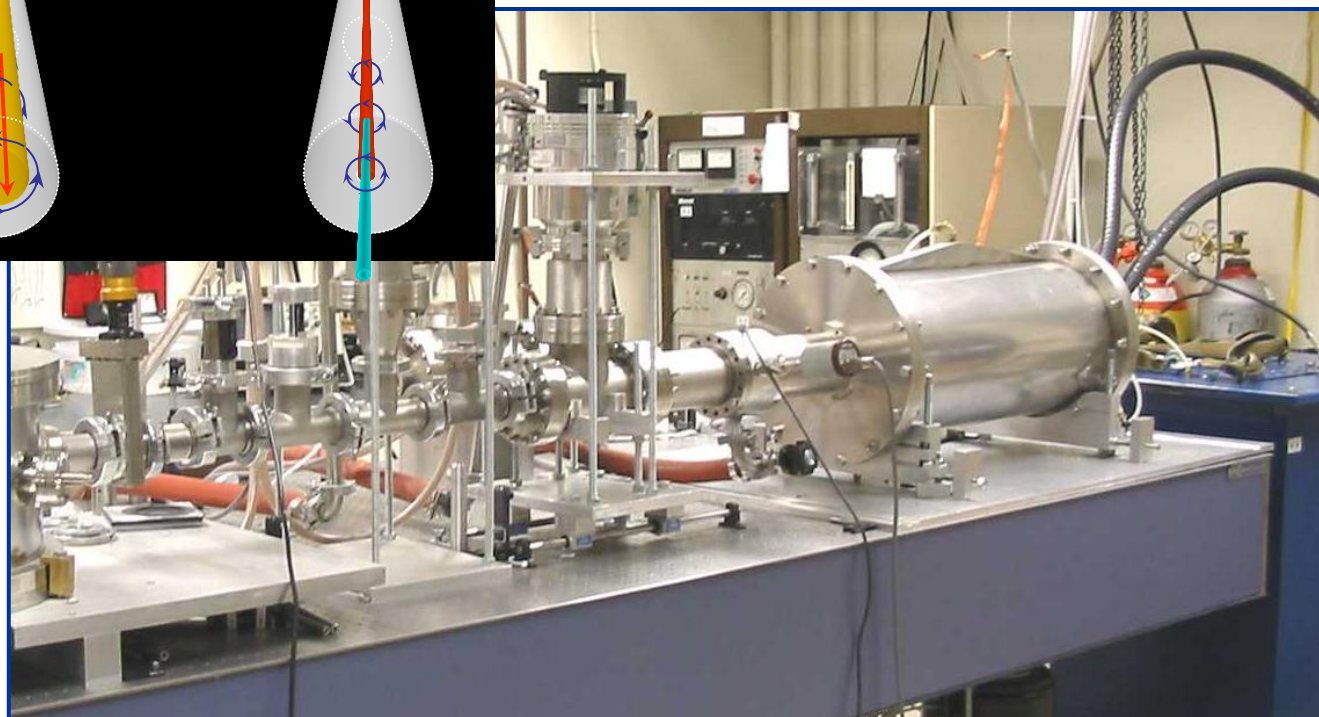
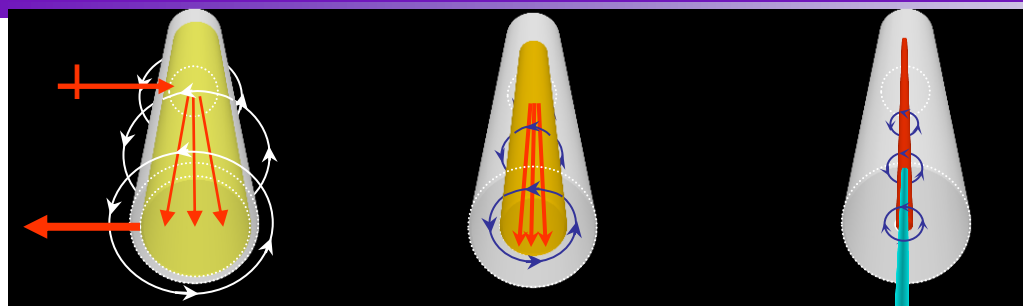
Discharge created plasma

$$h\nu = \Delta E \propto Z^{2.5}$$



Ionized 20 times

Table-top laser in Ne-like Ar produces coherent average power at $\lambda=46.9$ nm similar to synchrotron beam line

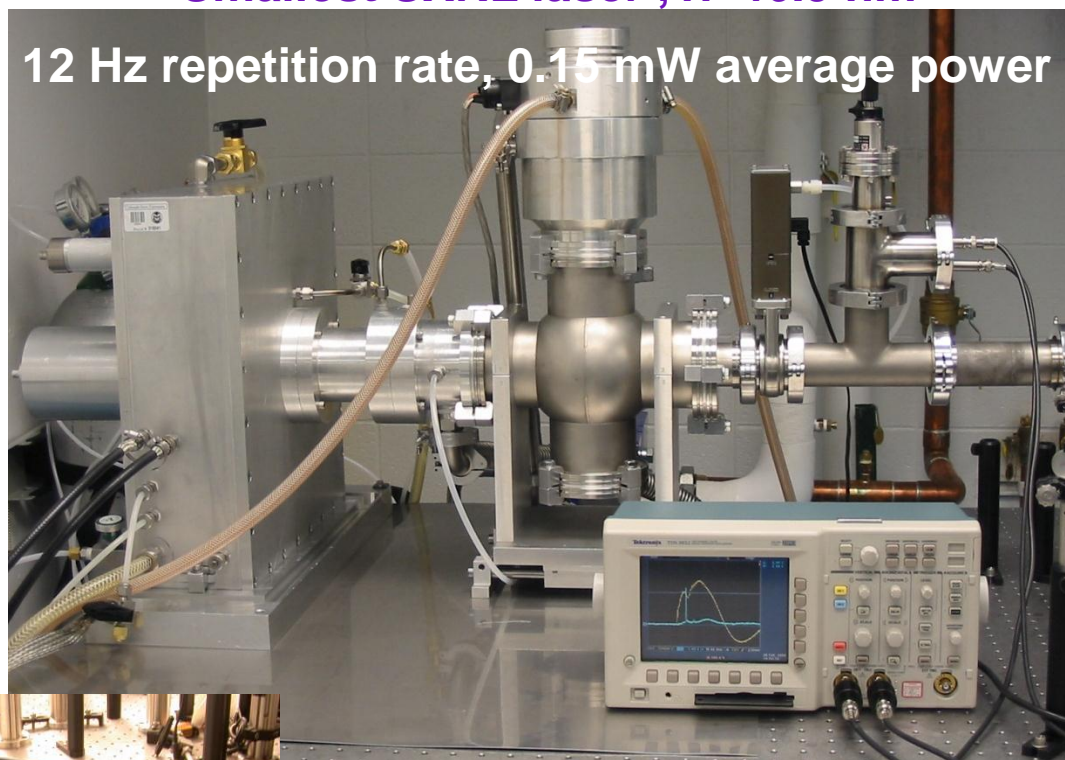


Ne-like Ar Capillary discharge 46.9 nm laser
High average power: up to 3 mW
High pulse energy: 0.1 mJ - 0.8 mJ @4 Hz
Narrow spectral bandwidth: $\Delta\lambda/\lambda = 3 \times 10^{-5}$
Beam divergence: $\theta = 4.5$ mrad

Recent research has shrunk capillary discharge SXRL to desk-top size

Smallest SXRL laser , $\lambda=46.9$ nm

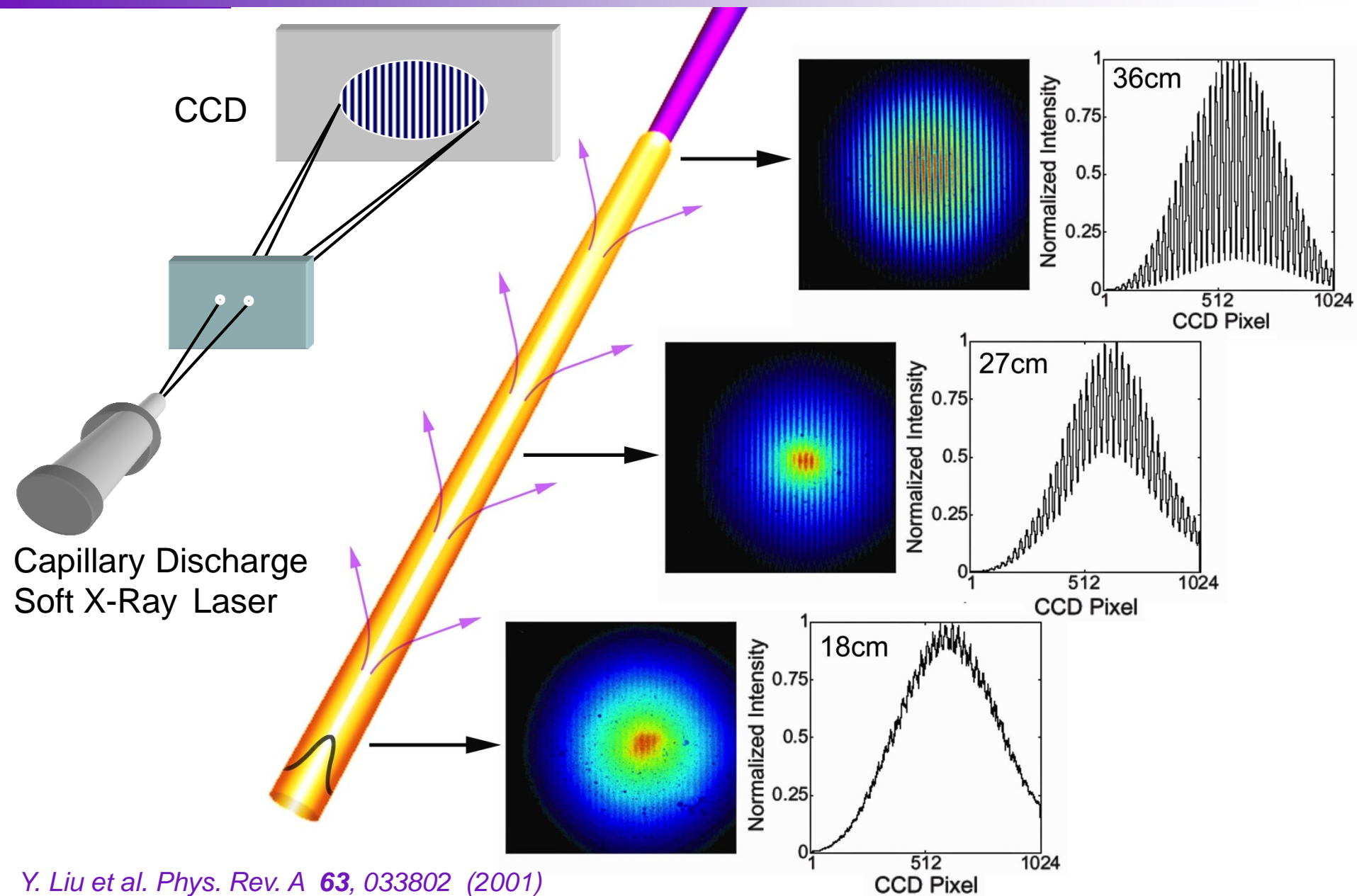
12 Hz repetition rate, 0.15 mW average power

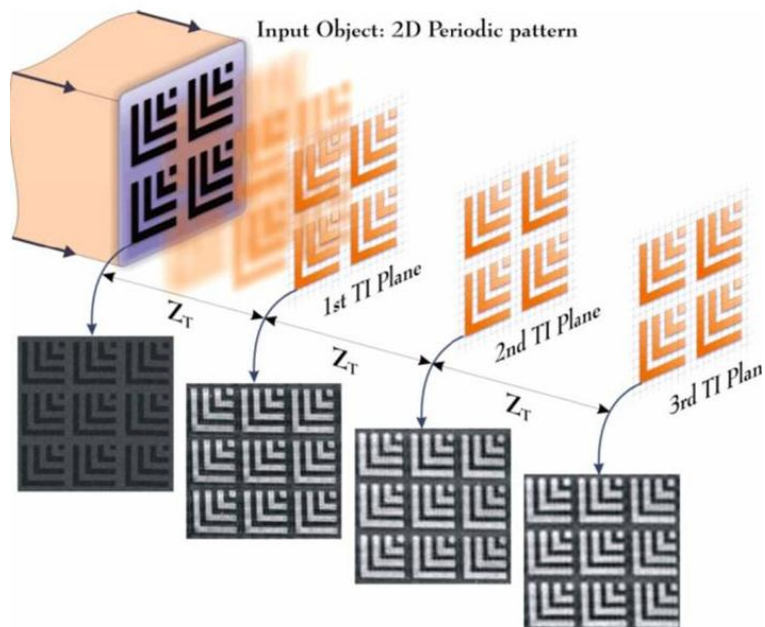


- 10 microjoule /pulse
- 0.15 mW average power
- 1-12 Hz repetition rate
- Pulse duration ~1.5 ns
- $\Delta\lambda/\lambda < 1 \times 10^{-4}$

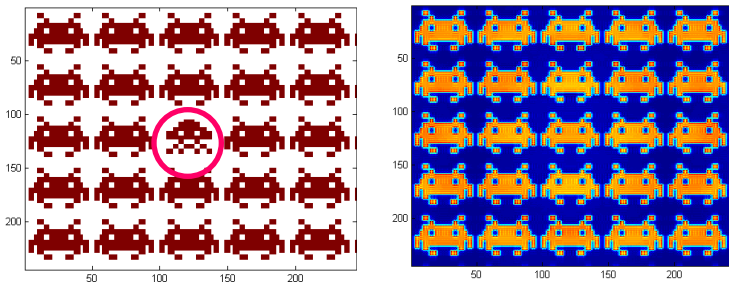
*S. Heinbuch, M. Grisham, D. Martz, J.J. Rocca
Optics Express, 30,2095, (2005)*

Essentially full spatial coherence is achieved increasing the capillary length



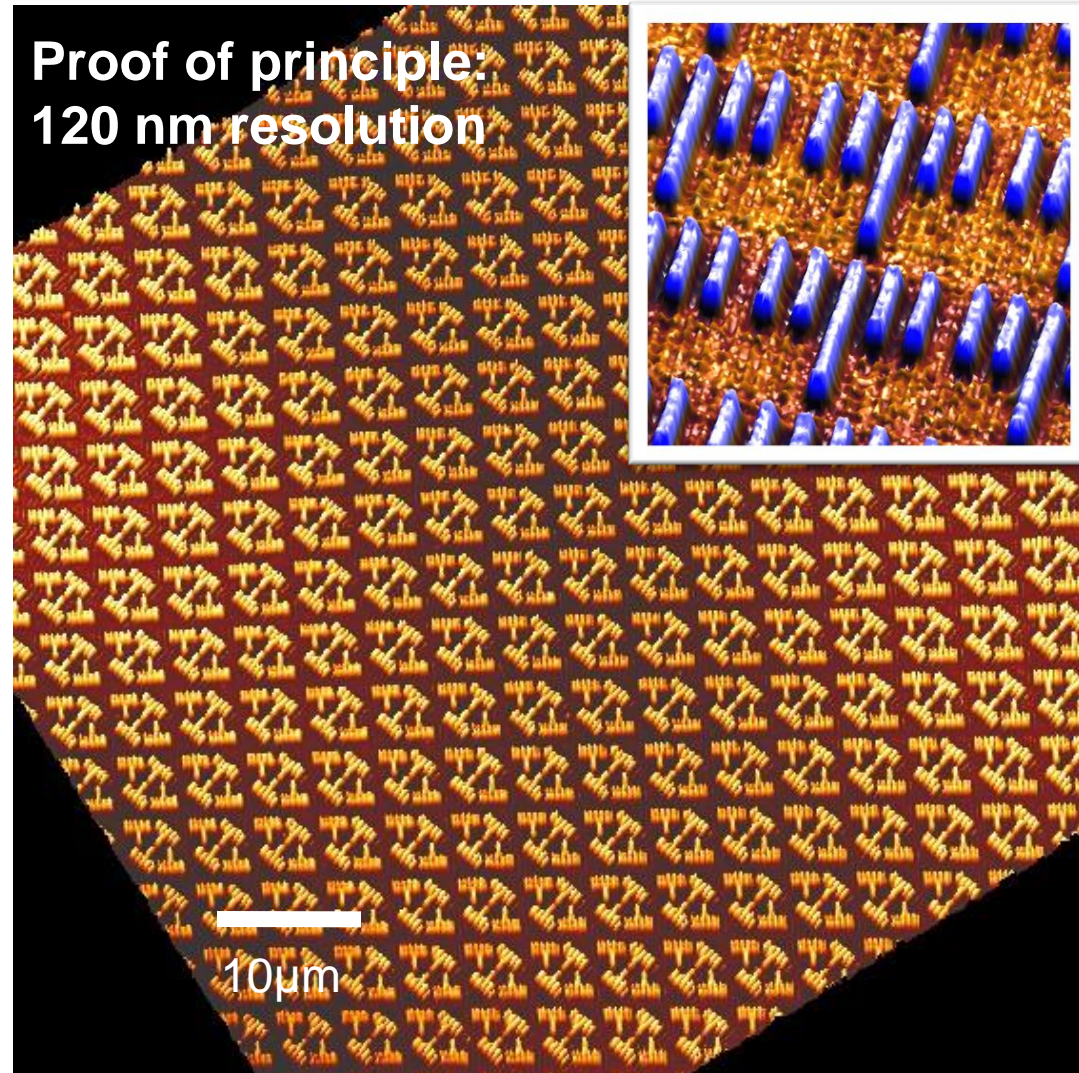


Error free printing



M. Marconi, F. Cerrina, et al. (2009)

**Proof of principle:
120 nm resolution**



A. Isoyan et al. JVST B 37, 2931, (2009), L. Urbanski et al. Optics Letters (2012)

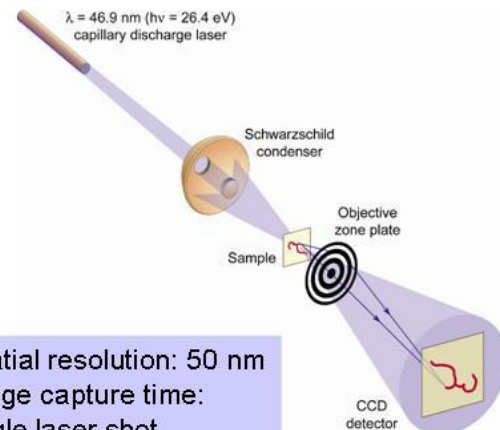
Compact $\lambda = 46.9$ nm full field microscope



46.9 nm SXR laser

Microscope
vacuum chamber

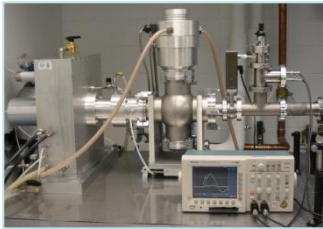
TRANSMISSION CONFIGURATION



Single shot image of
50 nm nanotubes

2 μ m

Courtney
BrewerFernando
Brizuela

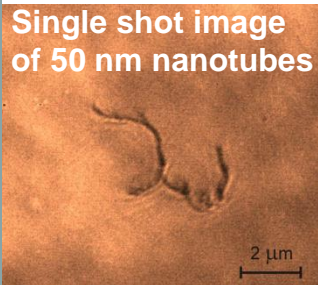


SXR laser

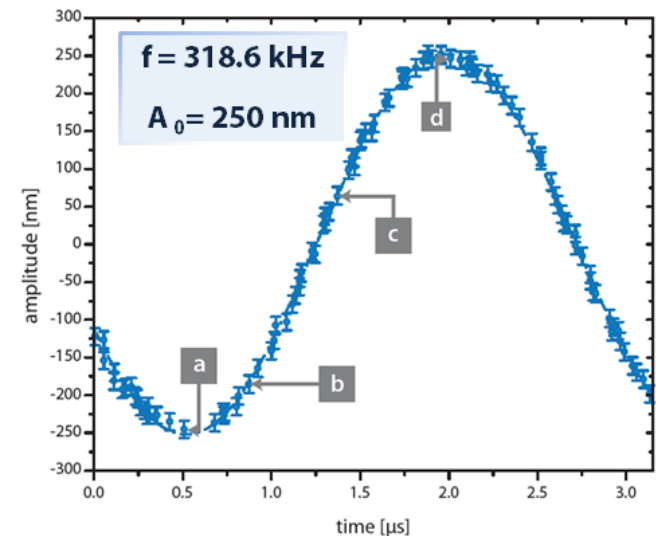
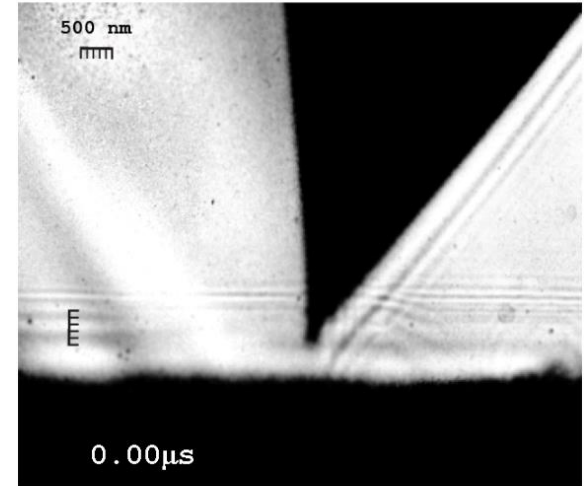
Sc/Si Schwarzschild
Condenser

319 kHz

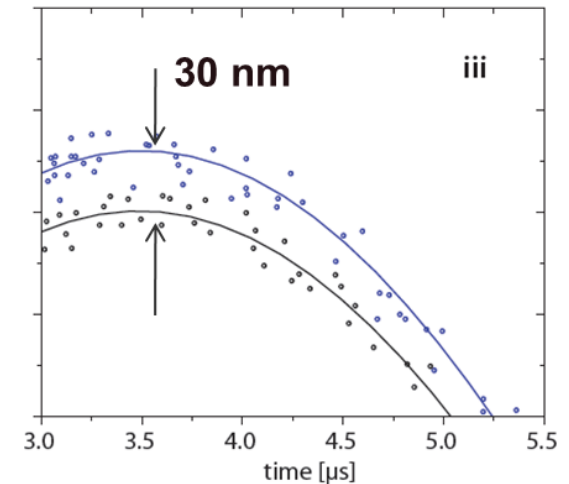
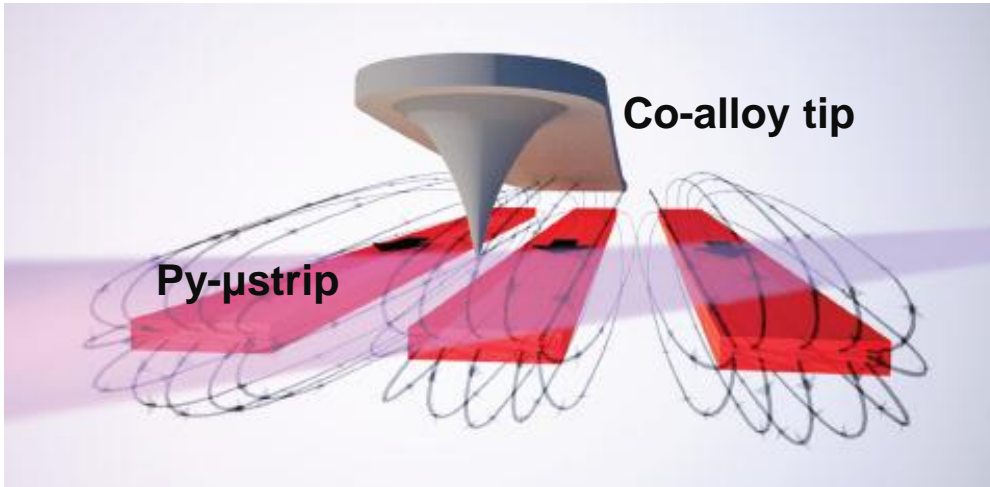
Nanoprobe

Freestanding
zone plateSingle shot image
of 50 nm nanotubesB. Brewer et al
Optics Lett.
33,518,(2008)

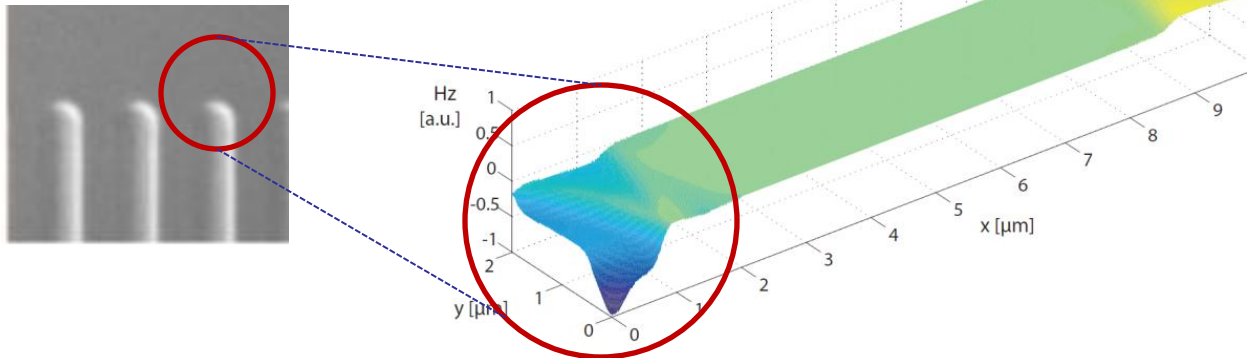
S. Carbajo et al. Optics Letters (2012)



Magnetic force microscope tip interaction with stray magnetic field

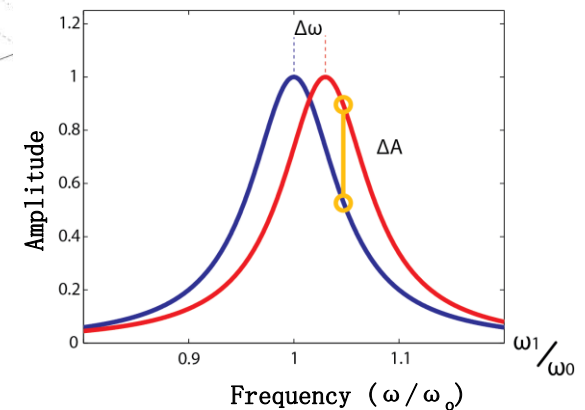


Magnetic field along z

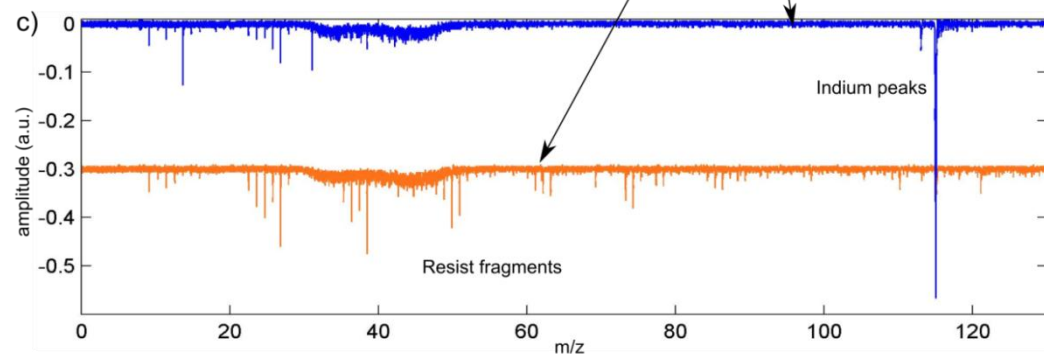
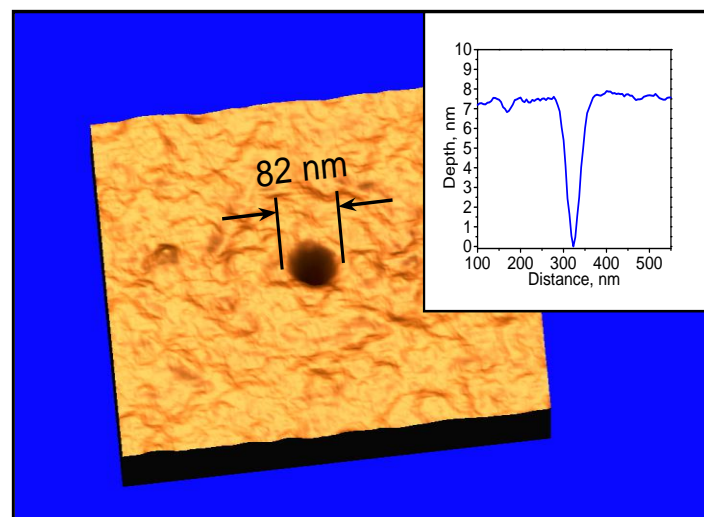
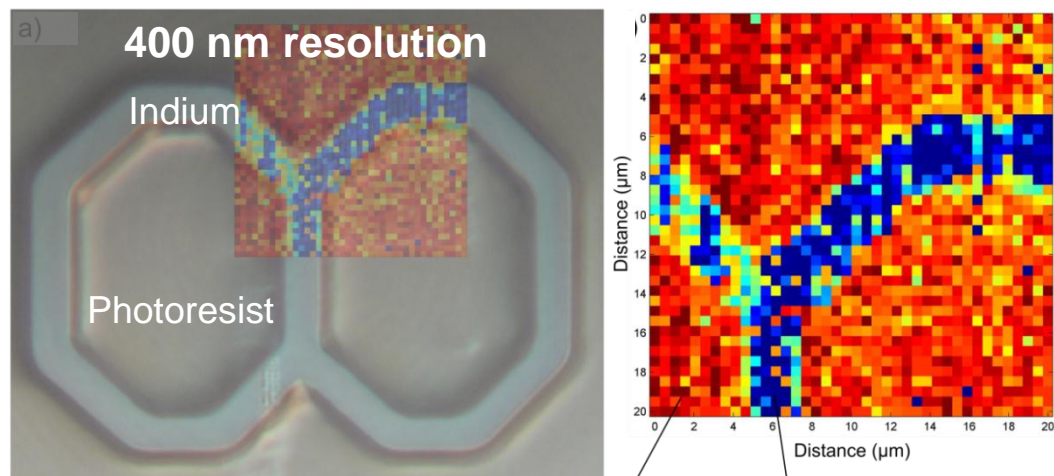
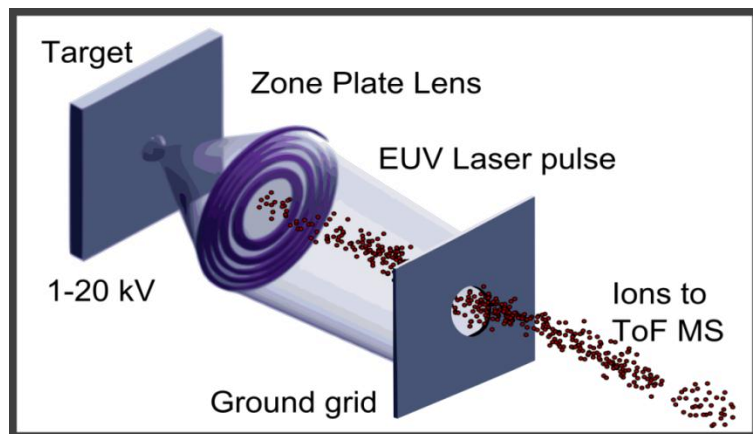


Effective Spring Constant
 $k_{\text{tip}} + k_{\text{force}}$

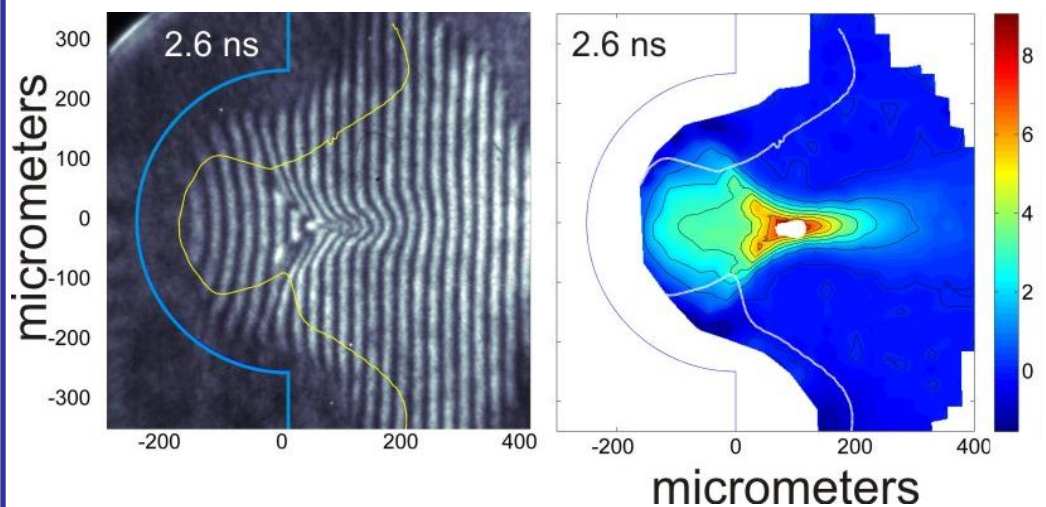
$$\omega_{\text{res}}^2 = k/m = 1/m (k - \partial F/\partial z)$$



3-D maps of materials composition with nanometer resolution

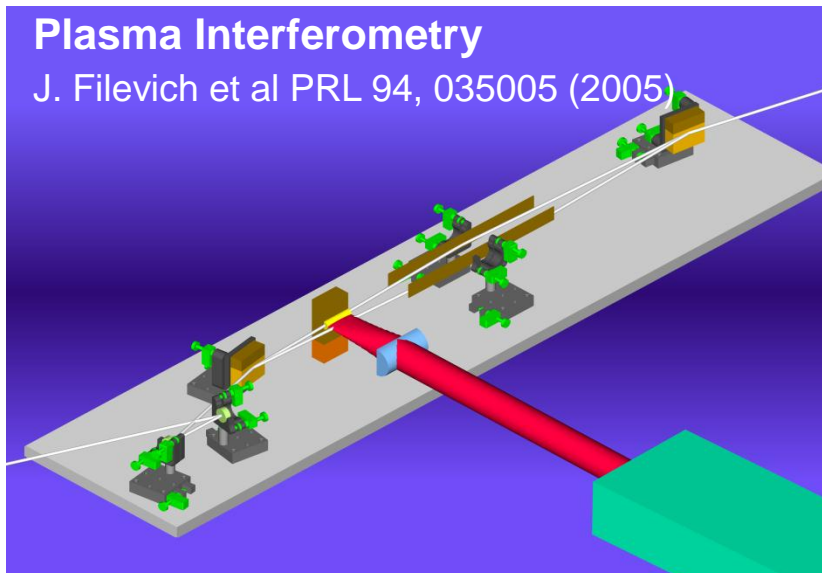


Applications in dense plasma diagnostics and photochemistry

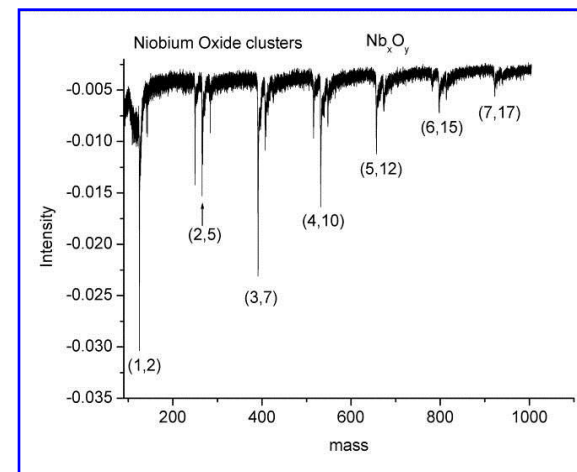


Plasma Interferometry

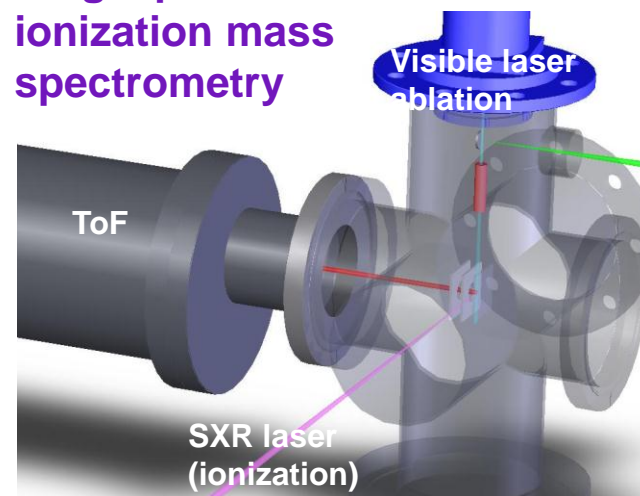
J. Filevich et al PRL 94, 035005 (2005)



M. Purvis et al. Phys. Rev.E, **76**, (2007); **124**, (2010)



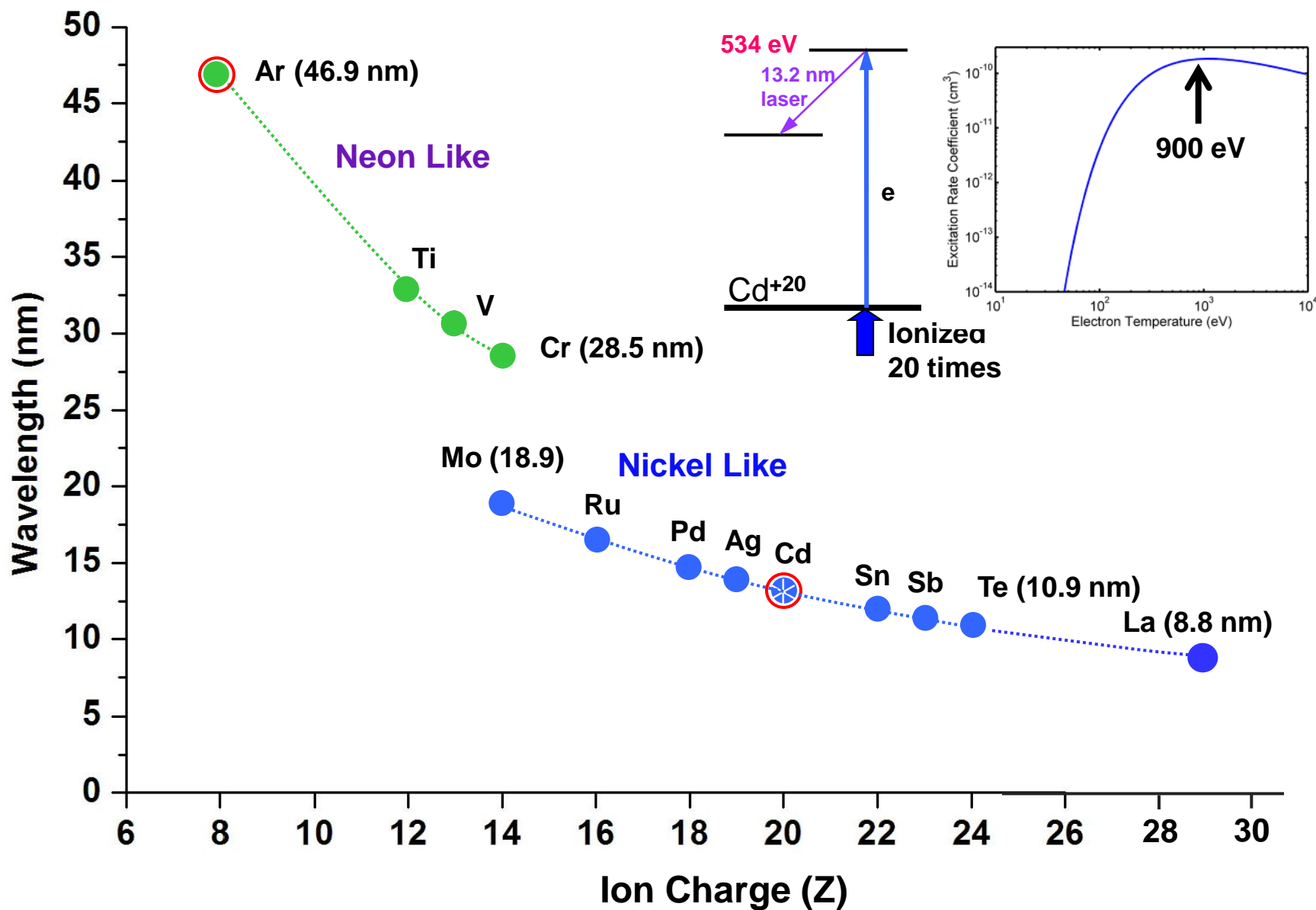
Single photon ionization mass spectrometry



F. Dong et al. J.Chem.Phys **124**, (2006)

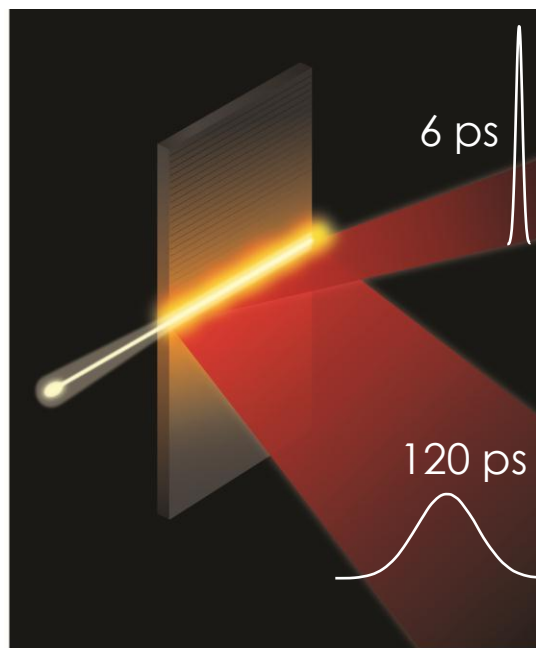
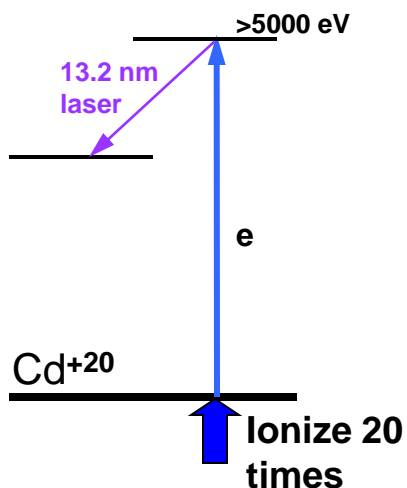
F. Dong et al. J.Am.Chem Soc. **131**, (2009)

Scaling to shorter wavelengths requires hotter-denser plasmas

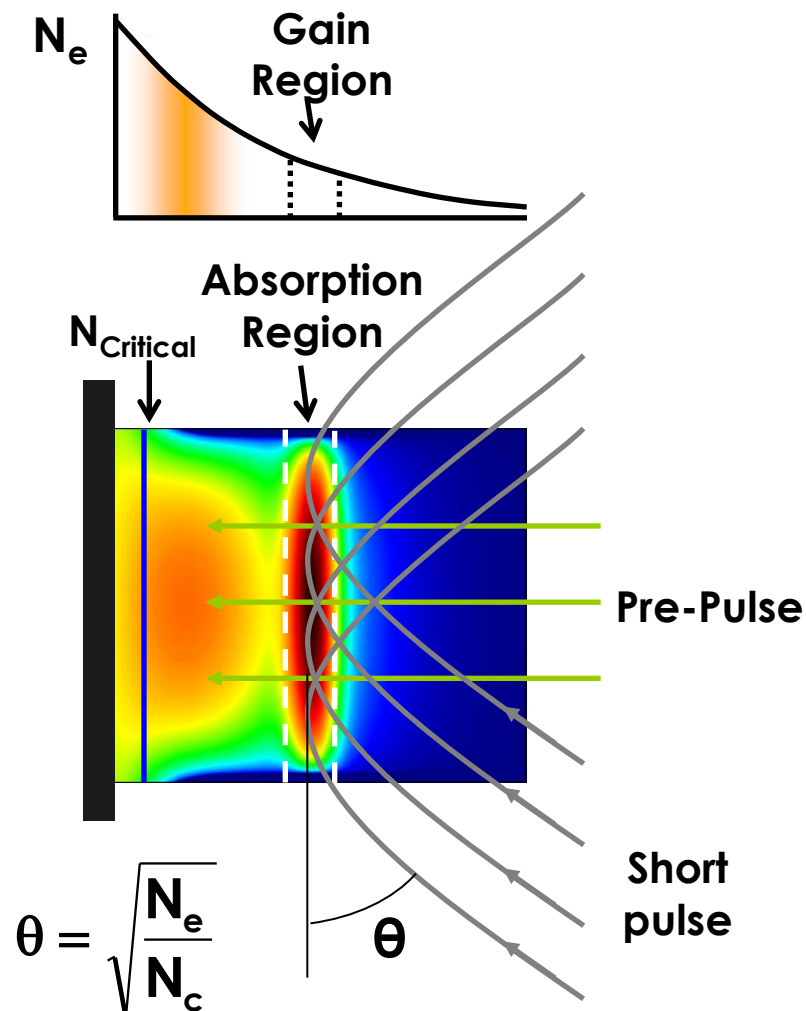


Soft X-ray lasers excited by rapid heating of plasmas with short laser pulses

Laser Pumping Geometry



Grazing incidence allows for efficient heating of plasma region with optimum electron density

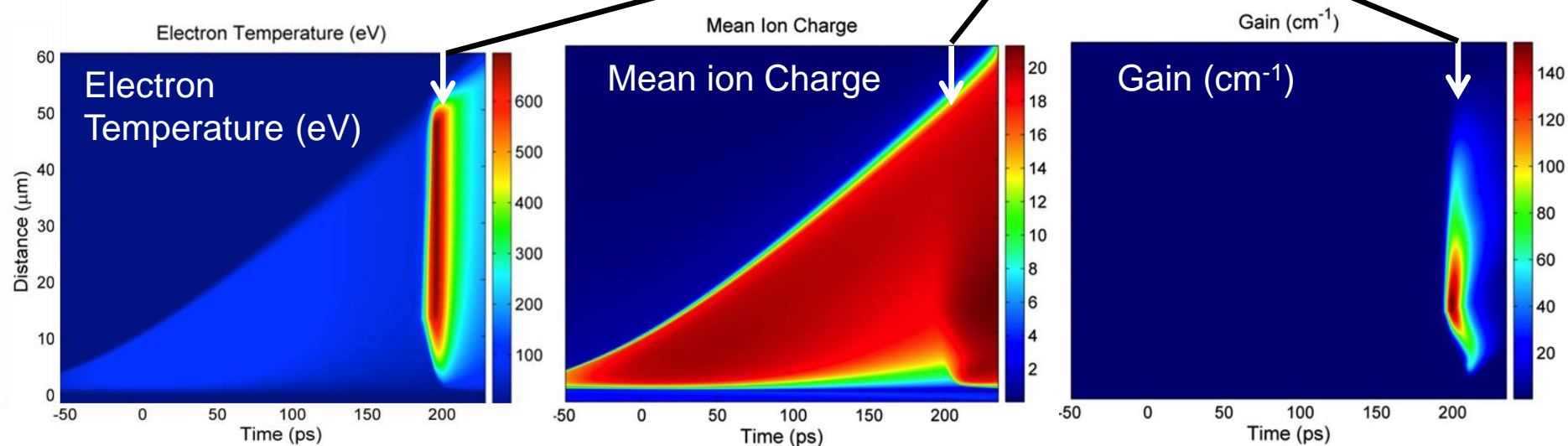
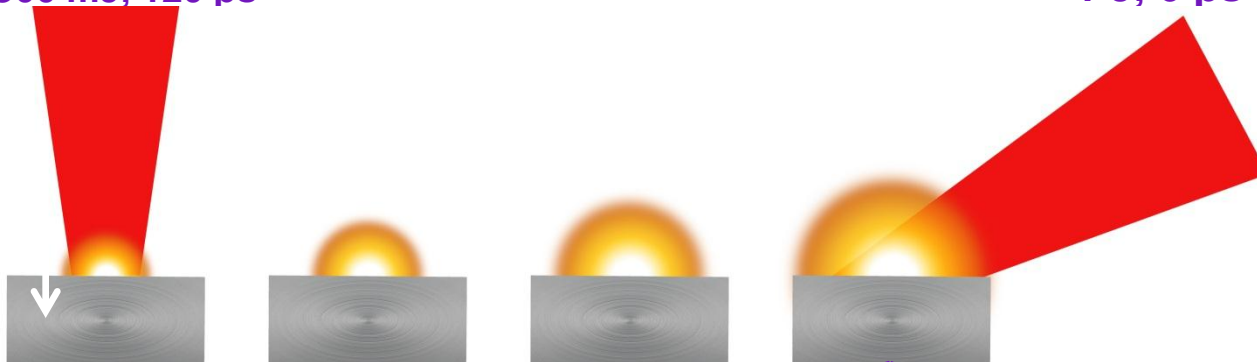


R. Keenan et al, *Phys. Rev. Lett.* 94, 103901 (2005) ; B.M. Luther et al, *Opt. Lett.* 30, 165 (2005);
Transient excitation: P. Nickels, V. Shlyaptsev et al. *Phys. Rev.Lett.* 78,2 748, (1997)

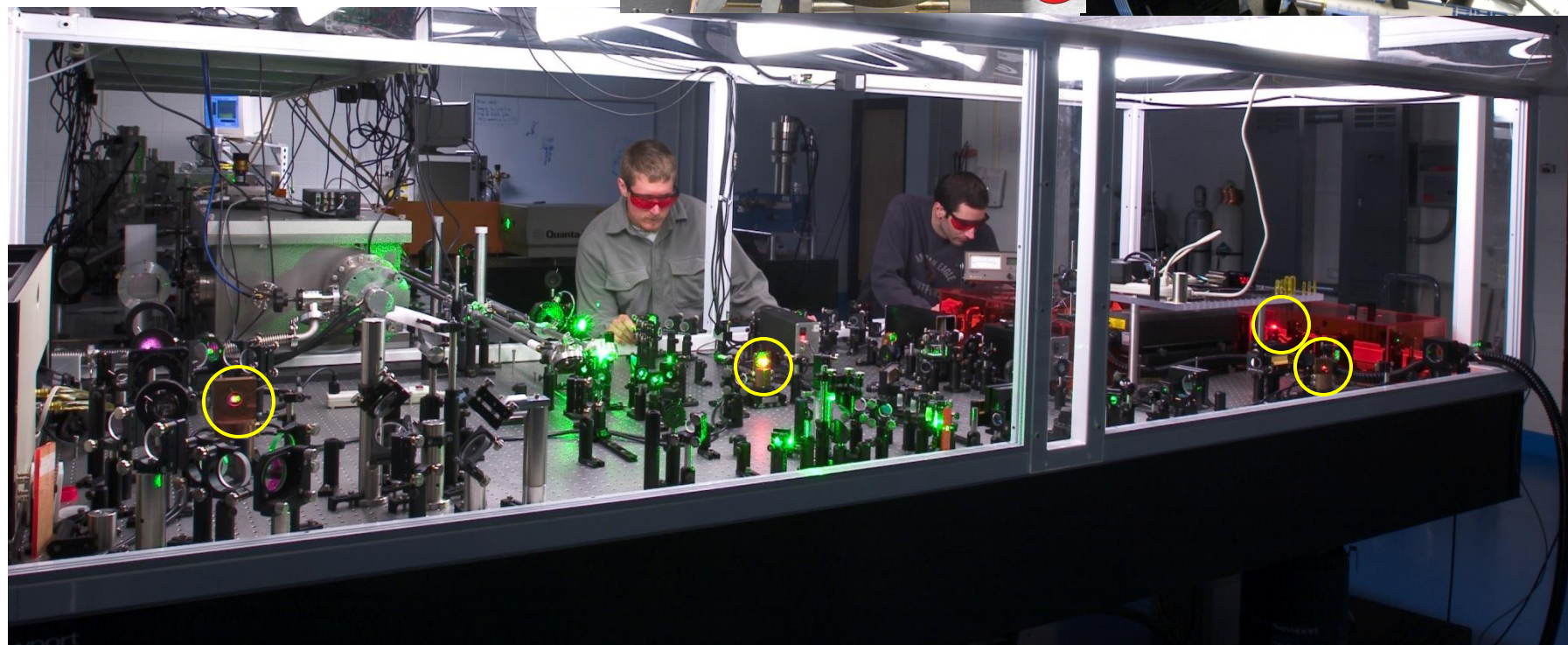
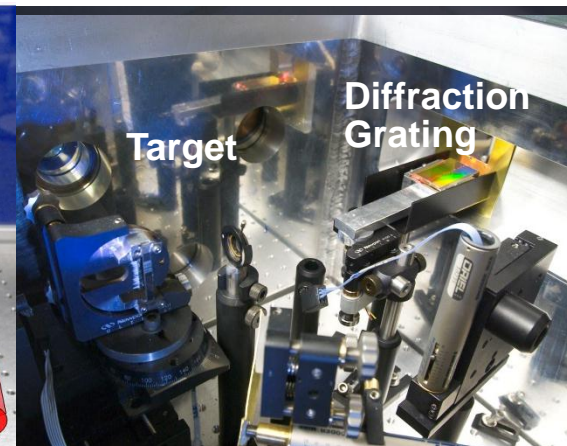
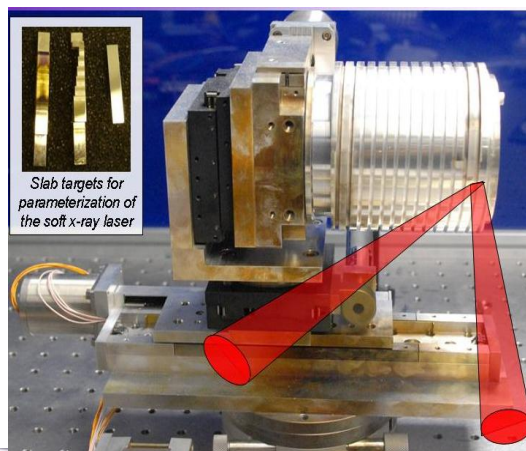
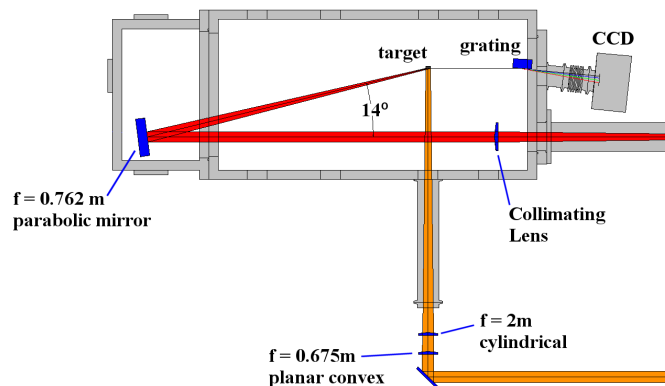
Simulation showed gain-saturated amplification at 13.2 nm in Ni-like Cd can be achieved with ~ 1 J pump

Pre-pulse
300 mJ, 120 ps

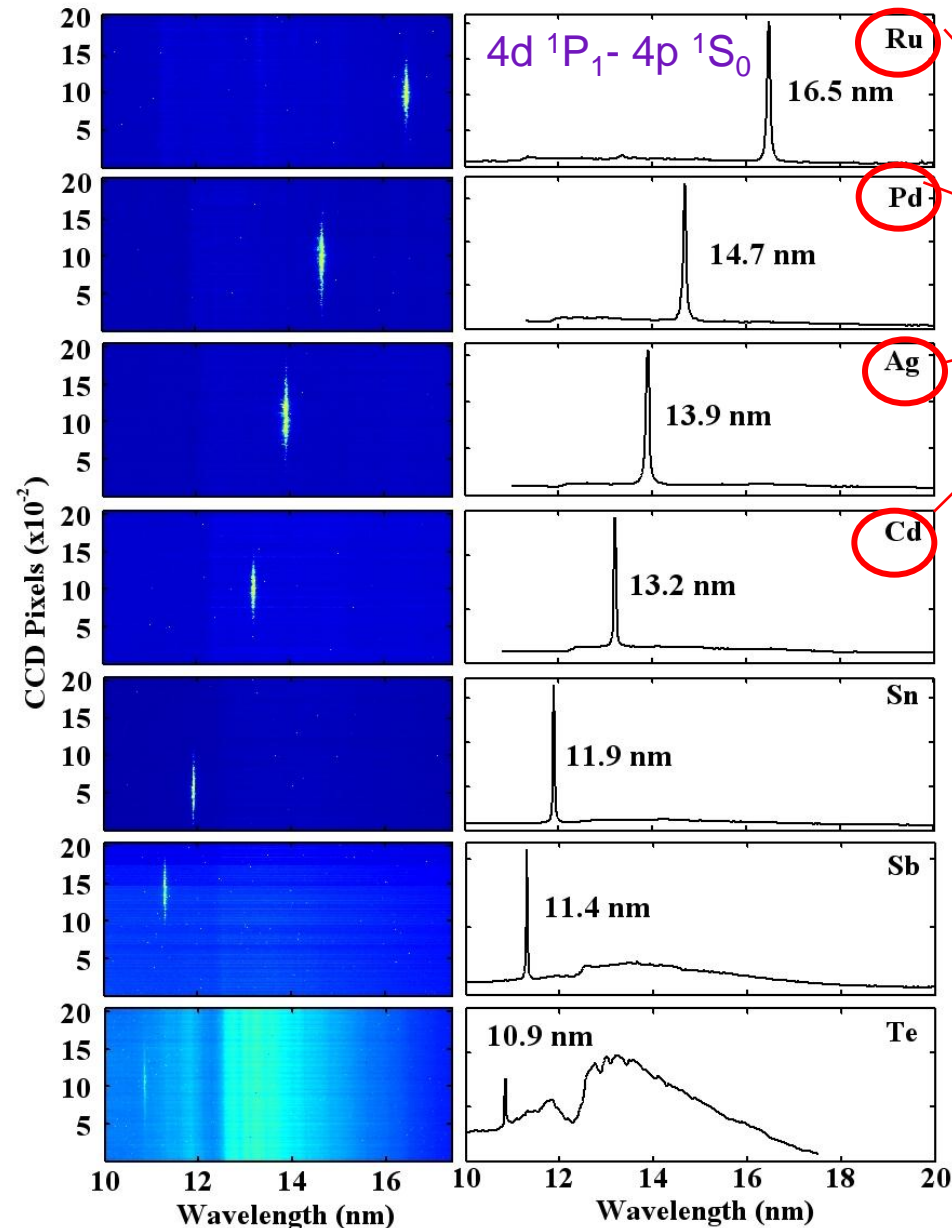
Heating pulse
1 J, 6 ps



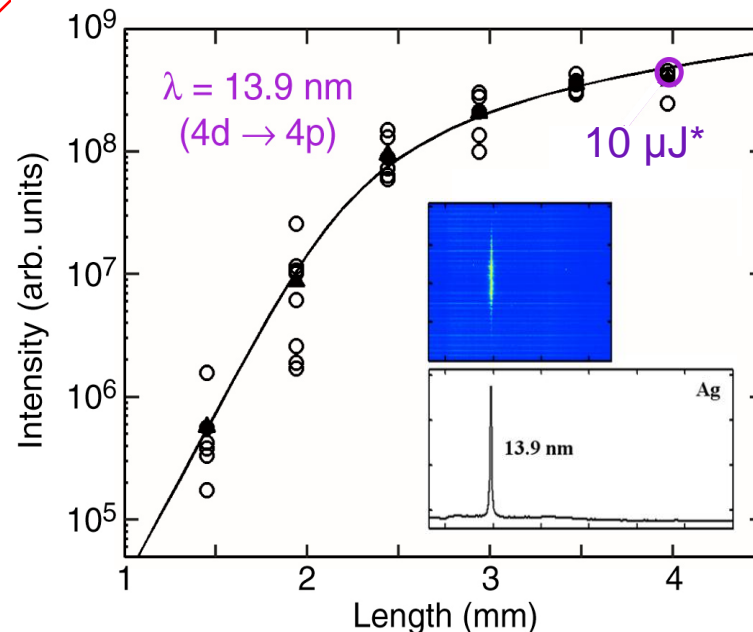
Lasers pumped by a 5-10 Hz ~ 1 J Short Pulse Table-top Ti: Sapphire System



High repetition rate table-top SXRL in transitions of Ni-like ions down to 10.9 nm

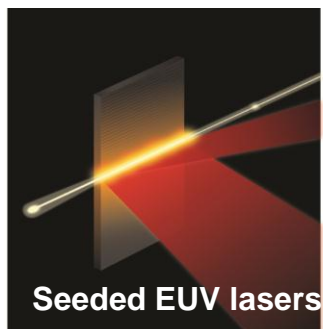
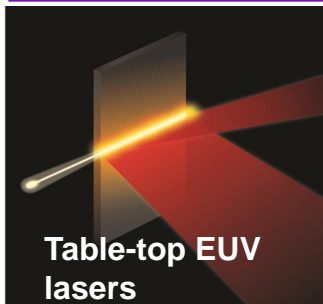


Gain saturated
operation
demonstrated



Y. Wang et al, *Phys. Rev. A* **72**, 053807 (2005)

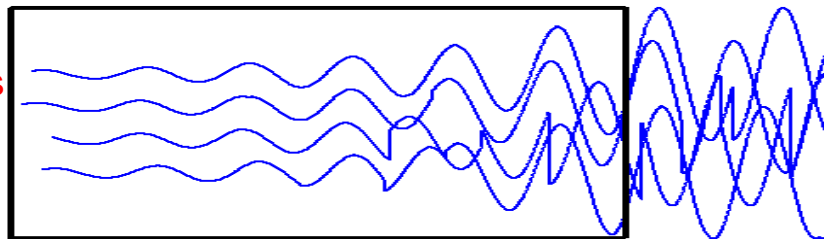
*D. Martz et al. *Optics Lett.* **35**, 1632 (2010)



Self-seeded

EUV Amplifier

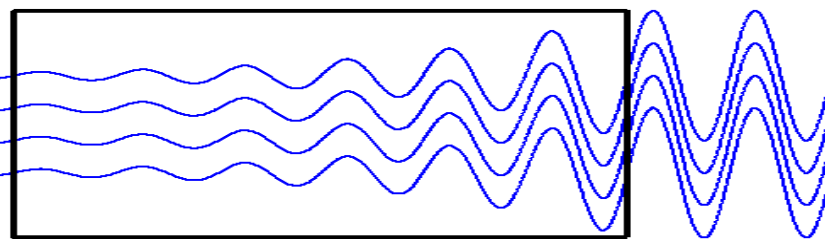
Spontaneous emission



Injection-seeded

EUV Amplifier

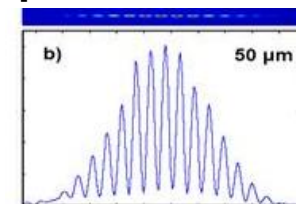
Coherent seed



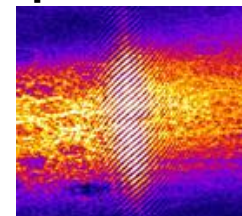
Seed pulses can be greatly amplified preserving or even improving their properties

Injection-seeding SXR Lasers have full phase-coherence and shorter pulsewidth

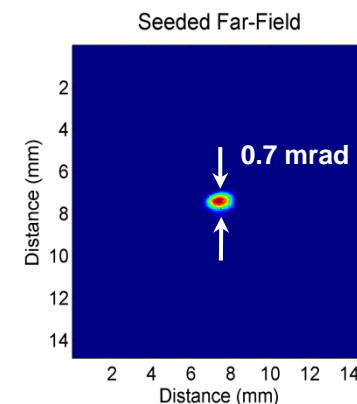
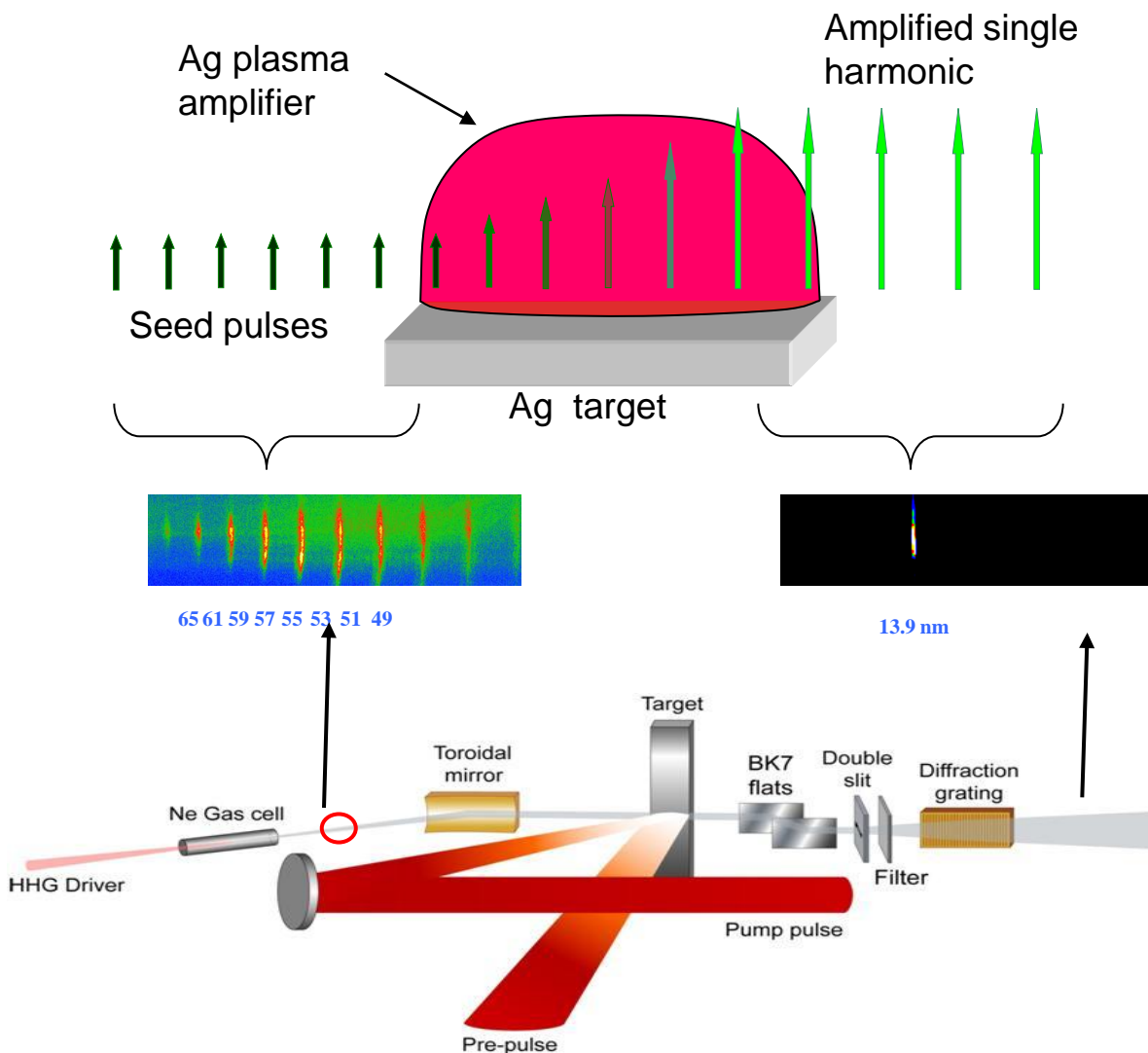
Full spatial coherence



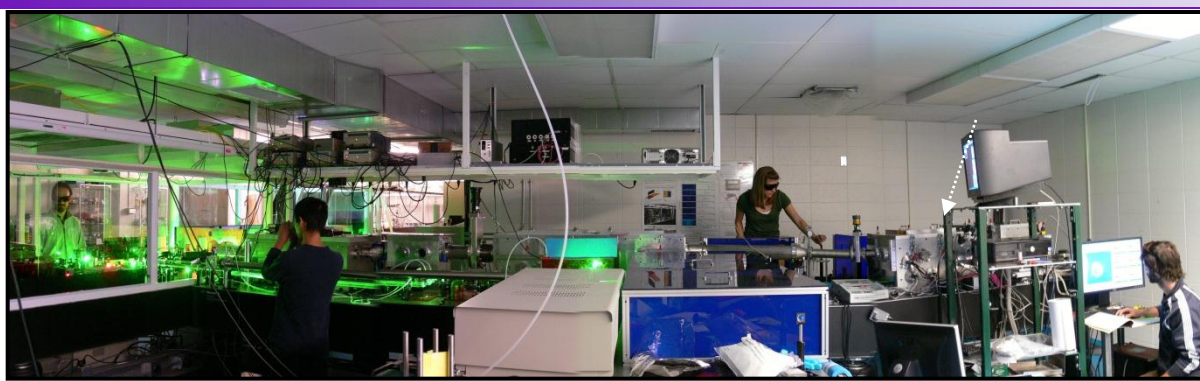
Full temporal coherence



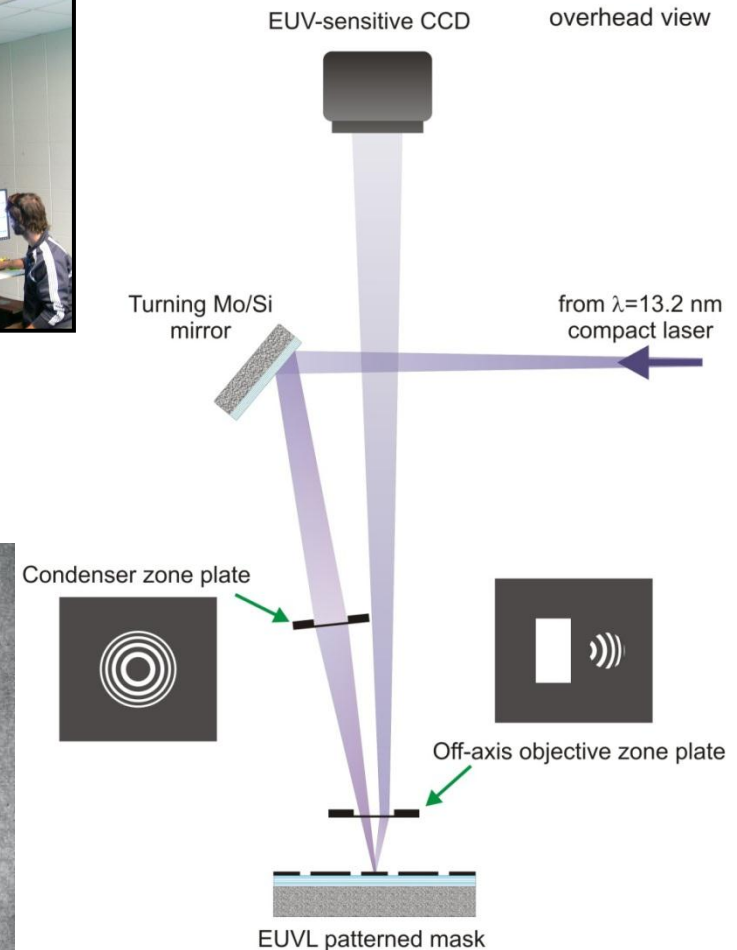
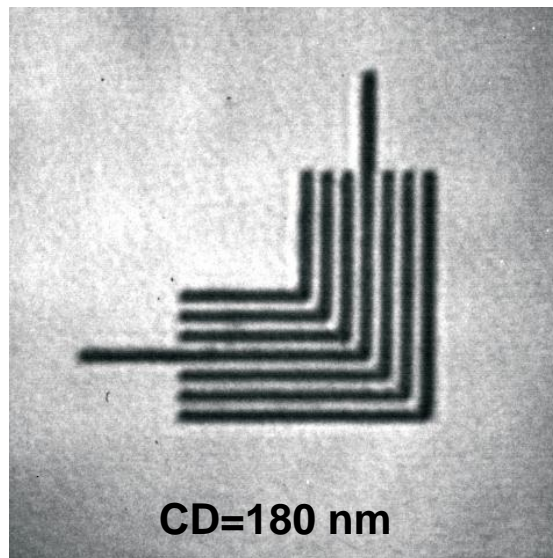
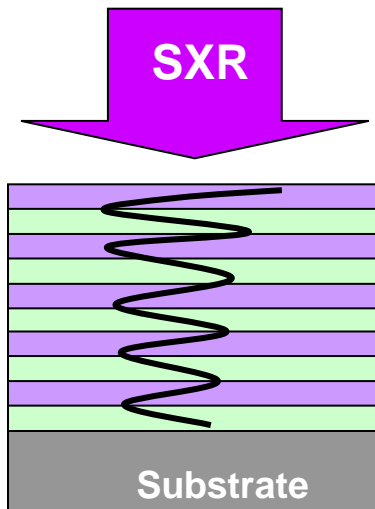
Shorter pulsewidth (1.13 ± 0.47)ps



13.2 nm laser-based microscope for defect inspection in EUV lithography masks

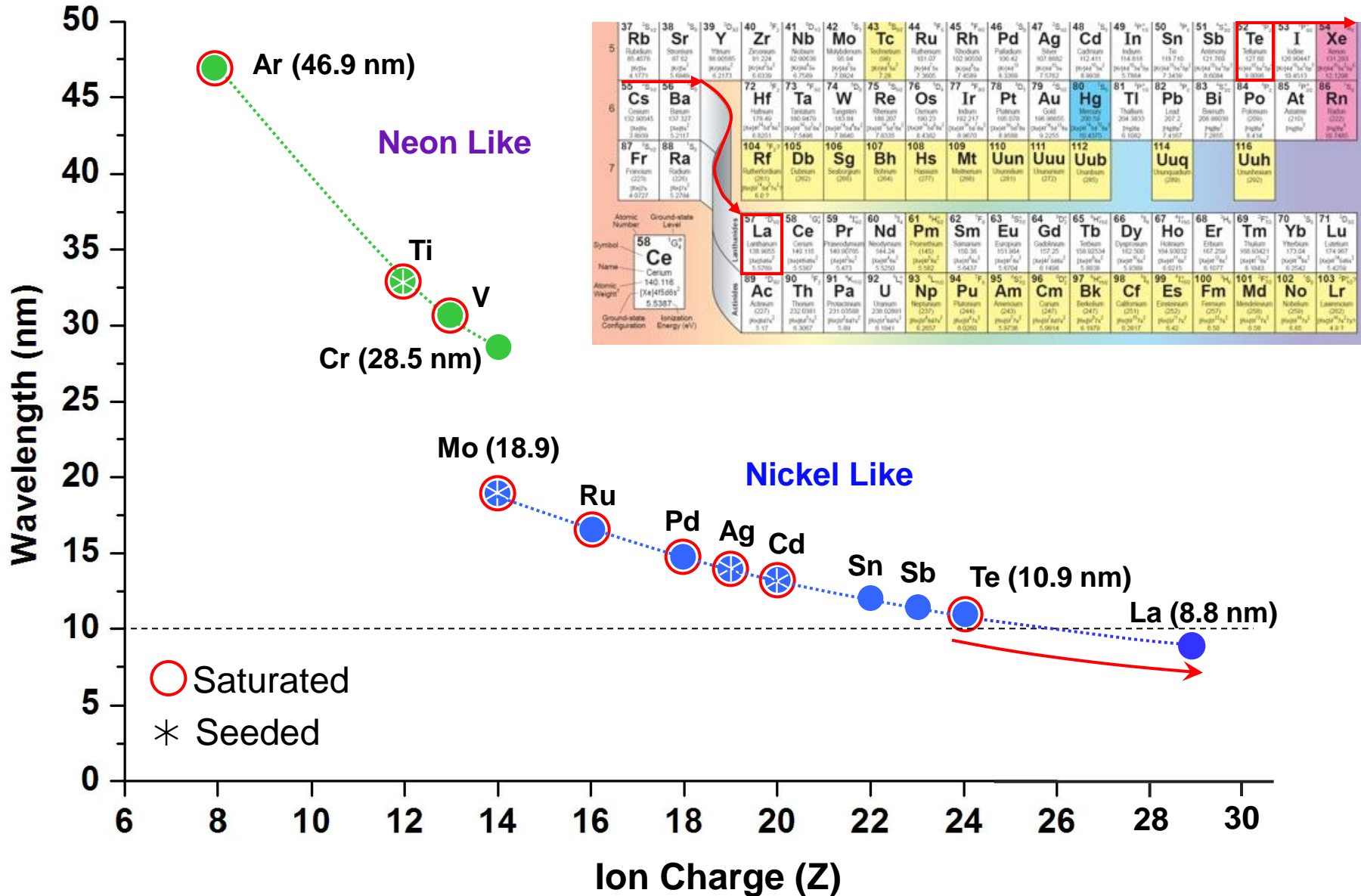


$\lambda = 13.2$ nm resonant with Mo/Si coatings in extreme ultraviolet lithography masks

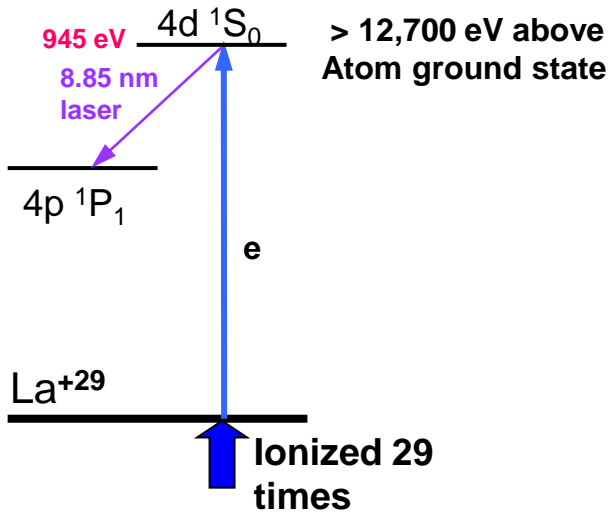


EUV Optics from CXRO, Berkeley

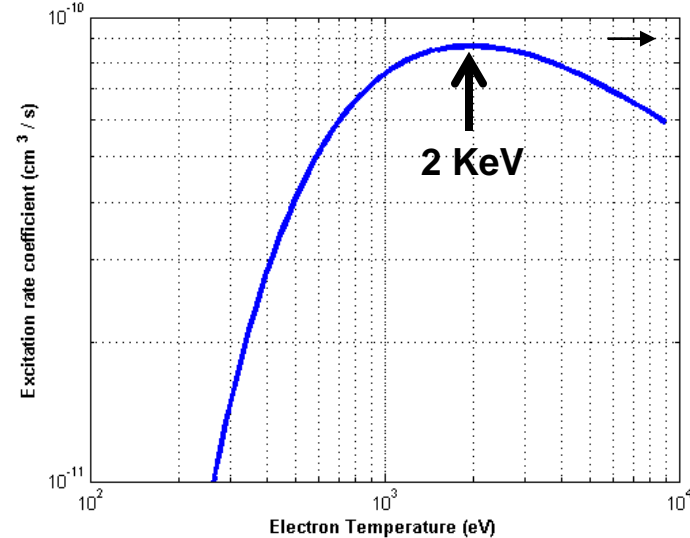
Extension of gain-saturated table-top SXRL to sub-10 nm wavelengths using lanthanide ions



Electron impact excitation of 8.8 nm La laser requires plasma with high electron temperature



Electron impact excitation rate 4d $1S_0$

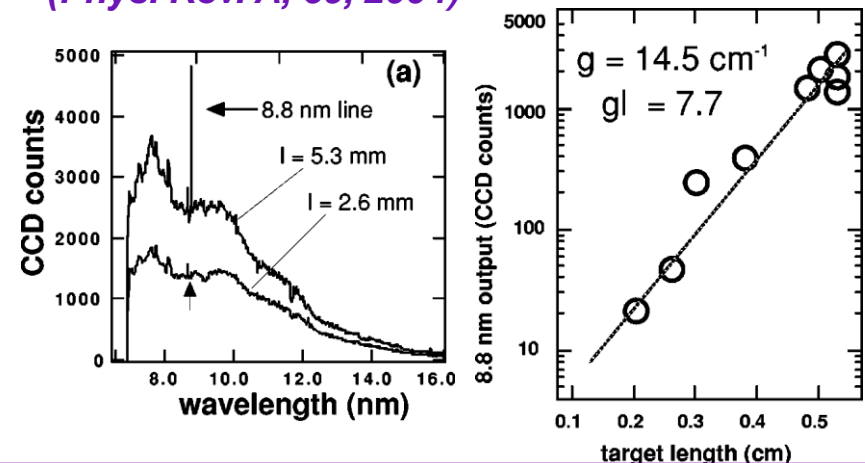
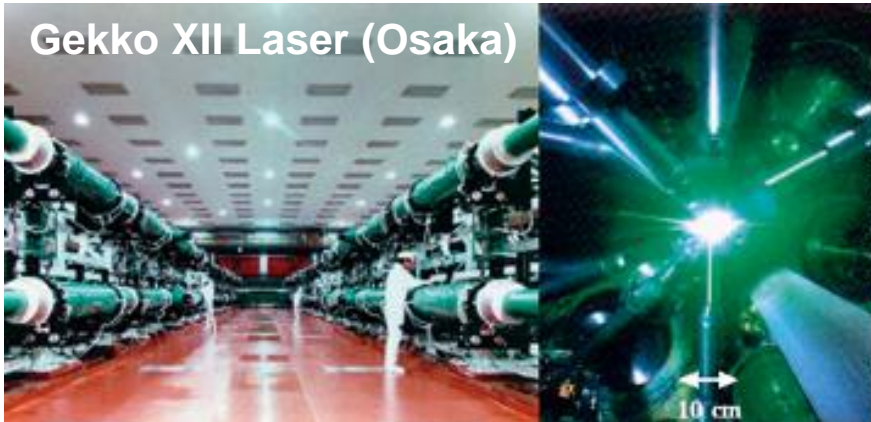


Previous work achieved unsaturated lasing at 8.8 nm in Ni-like La

•Daido et al. using 520 J of laser pump energy
(Optics Lett. 21, 958,1996)

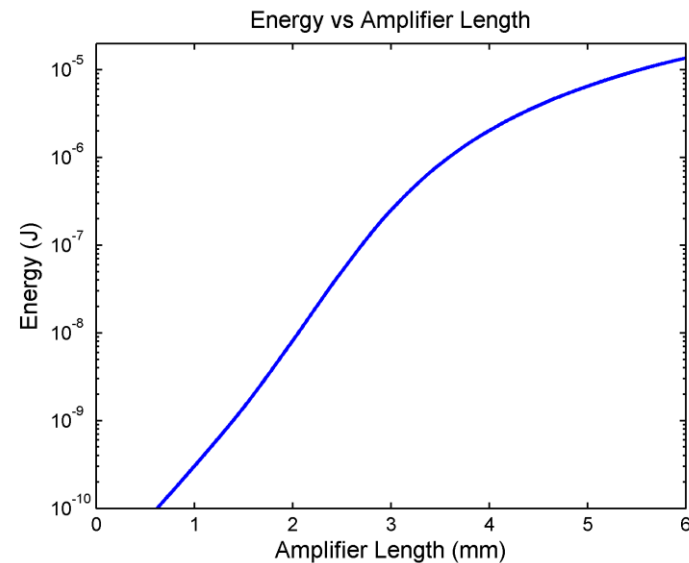
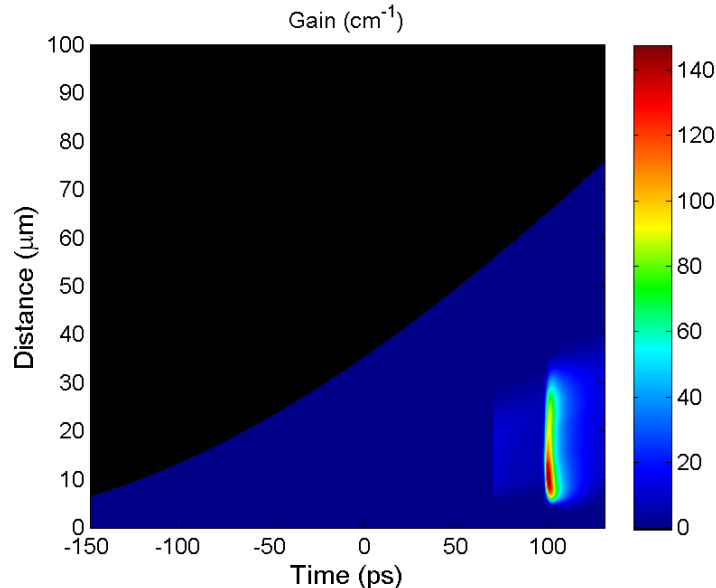
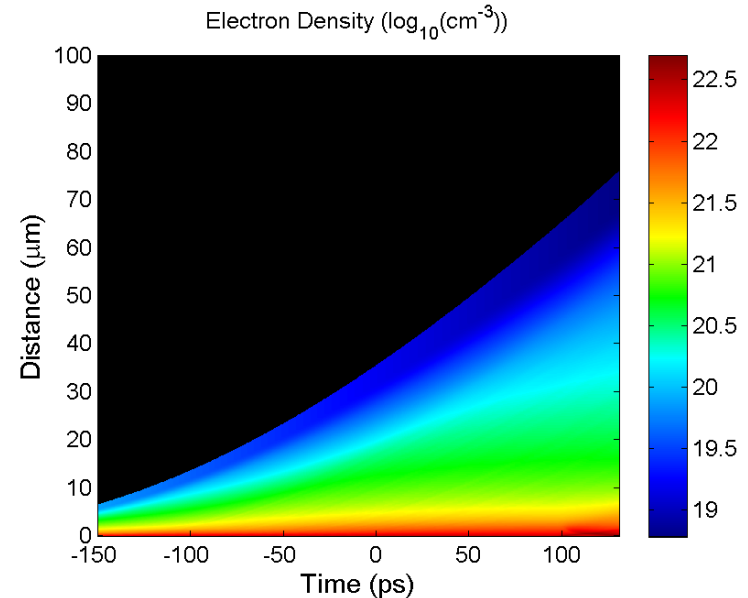
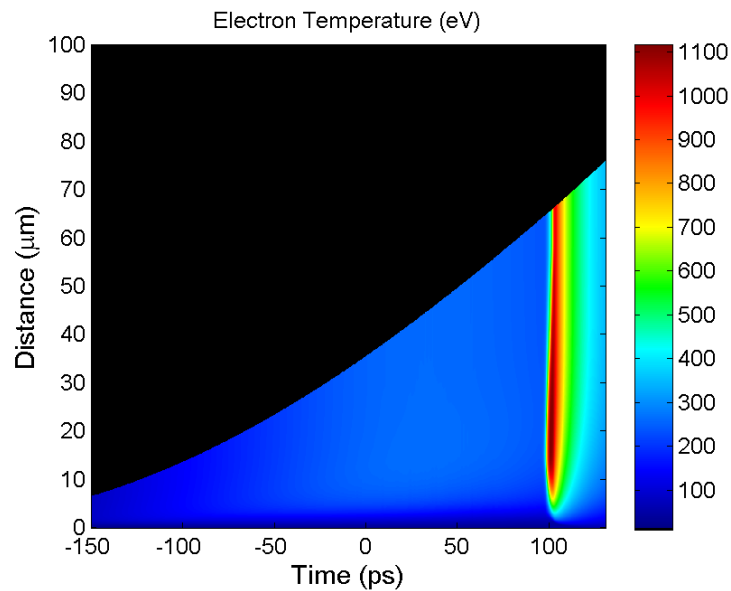
Kawachi et al. using 18 J picosecond pulses
(Phys. Rev. A, 69, 2004)

Gekko XII Laser (Osaka)



Simulation for 8.8 nm table-top Laser in Ni-like La predicts

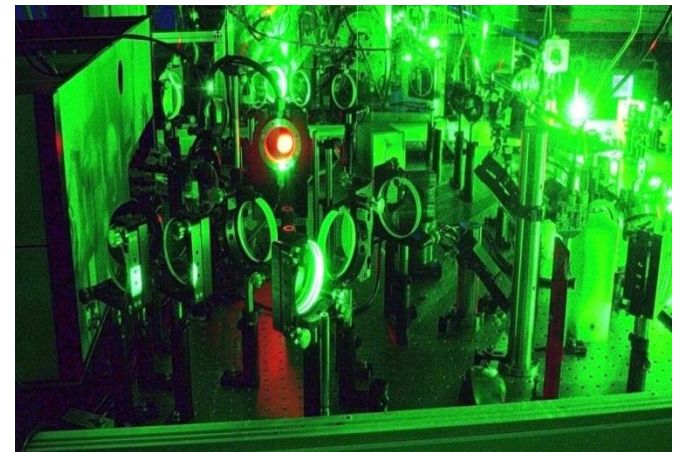
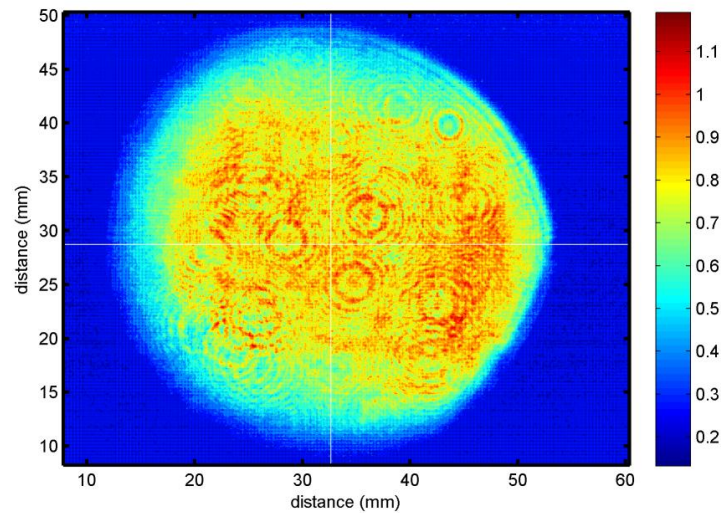
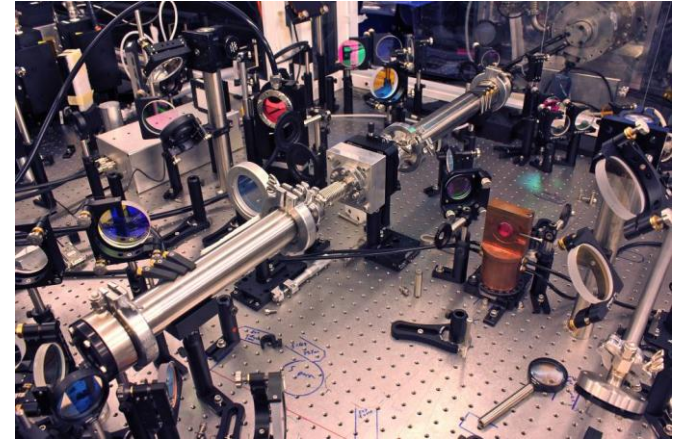
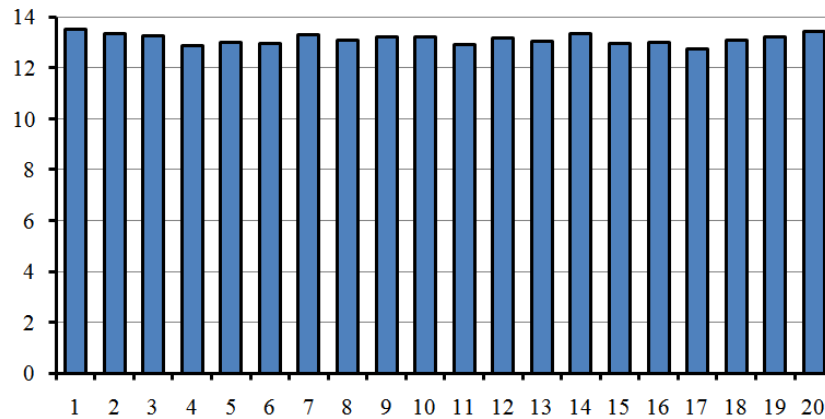
< 7 J pump energy needed for gain saturation

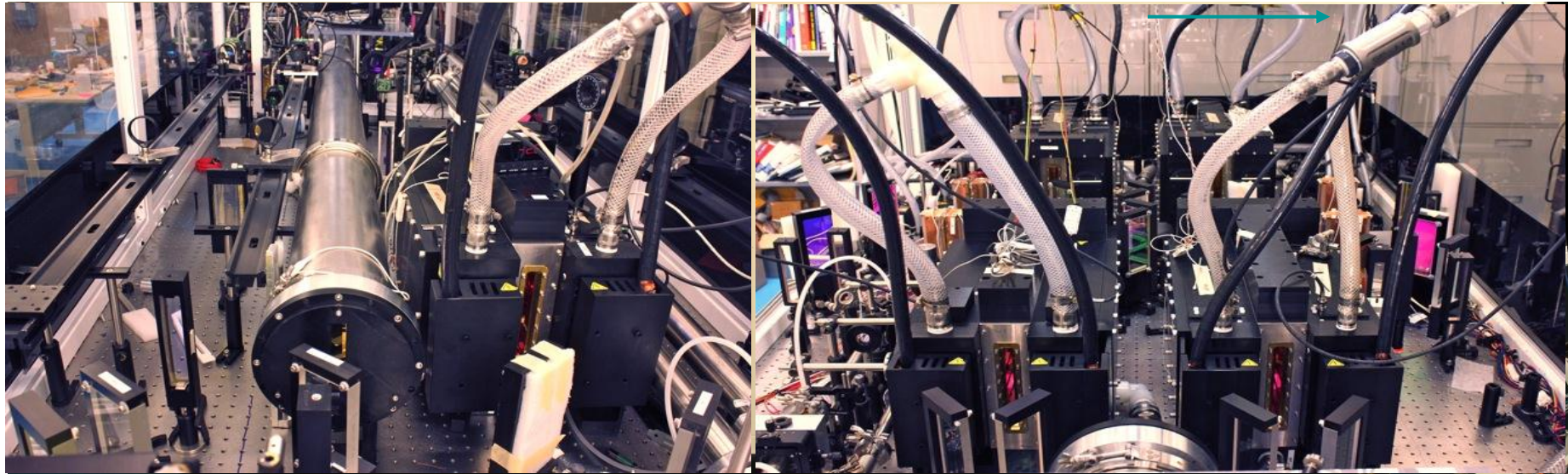
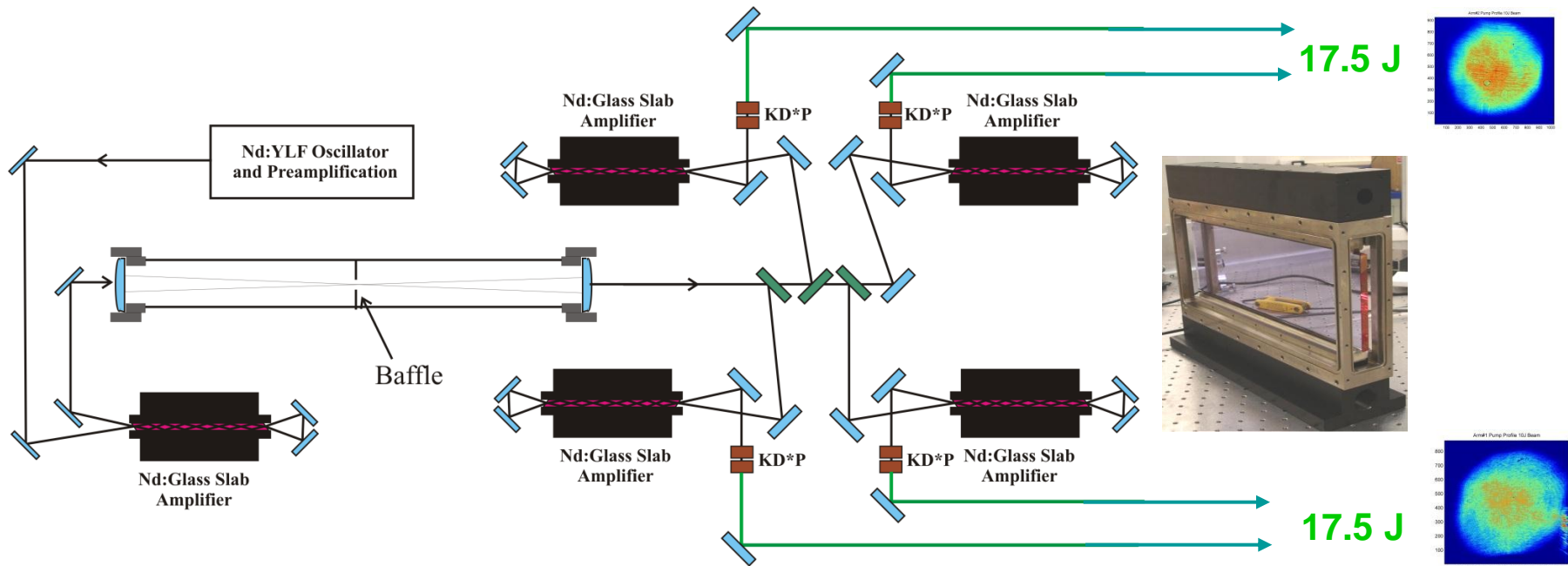


Simulation by Mark Berrill

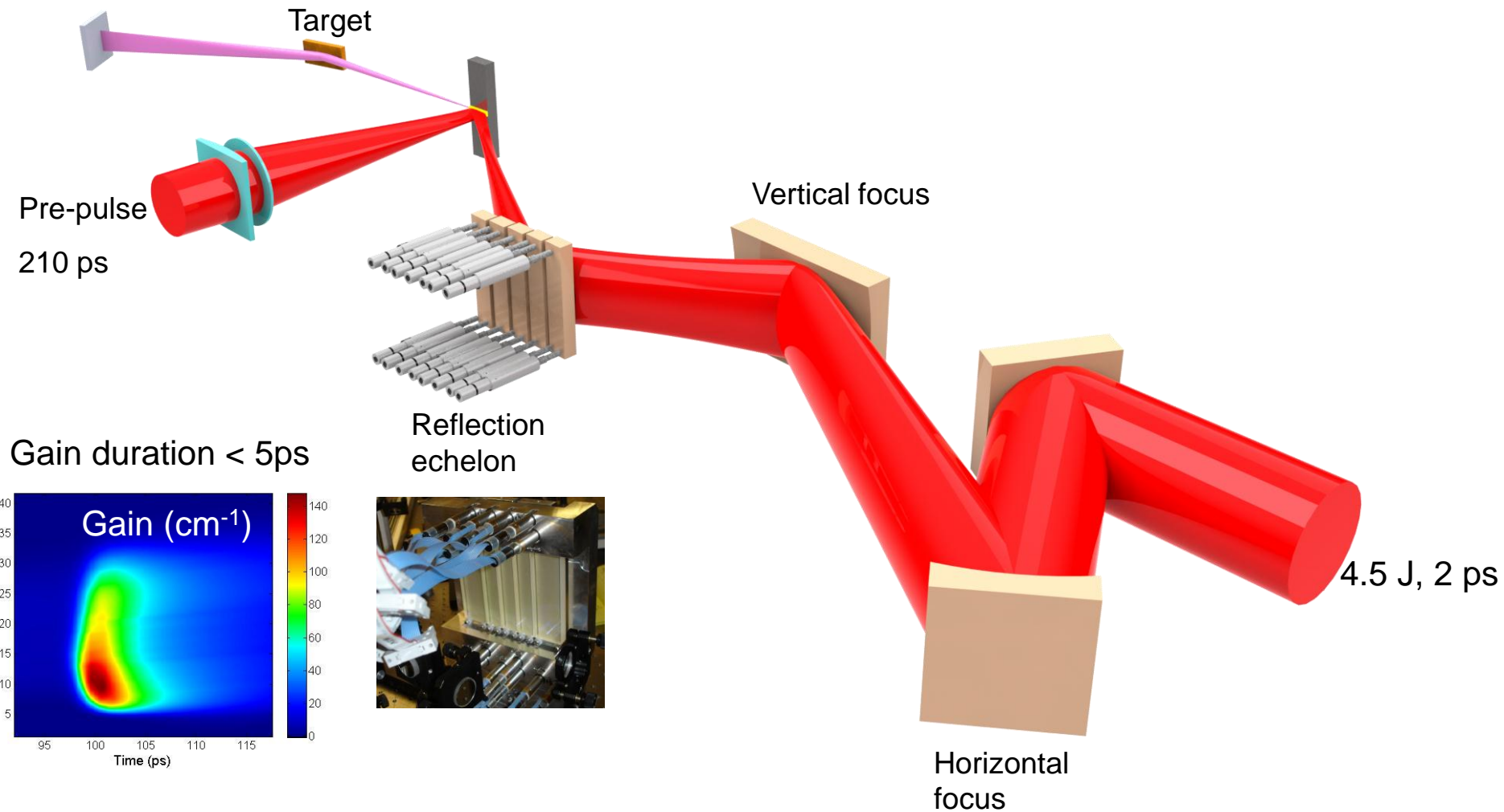
Titanium-Sapphire pump laser

Average Energy Pre-compression= 13 J
Std div. = 1.5 %



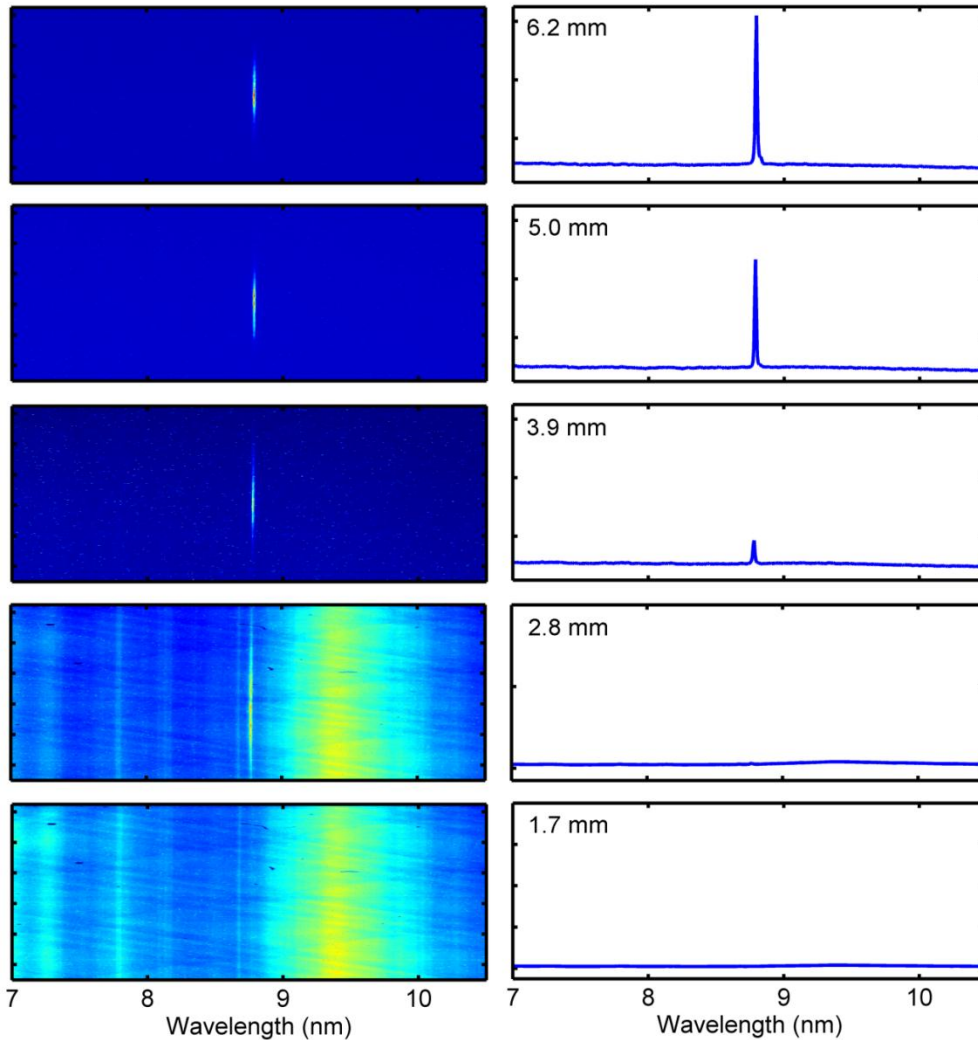


Gain-saturated sub-10 nm table-top lasers



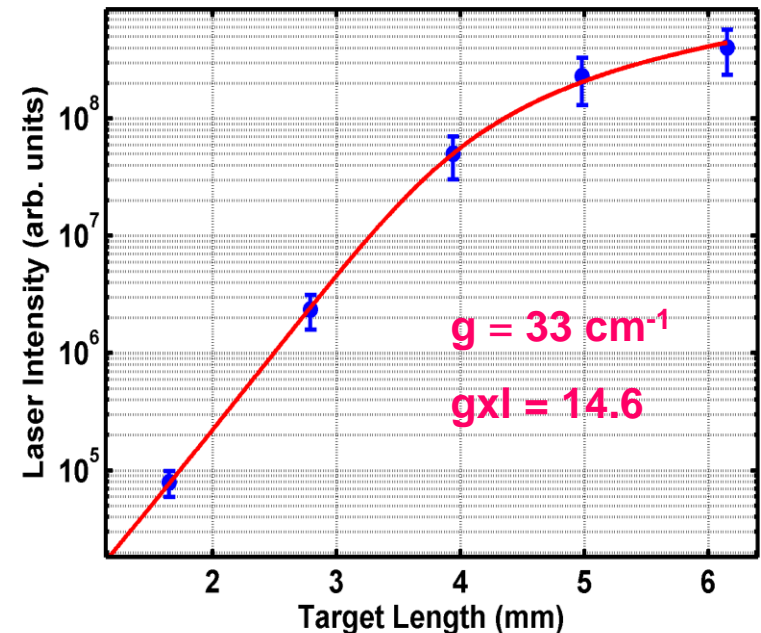
Demonstration of Gain-saturated table-top laser at 8.8 nm at 1 Hz repetition rate

Ni-like Lanthanum $4d^1S_0 - 4p^1P_1$



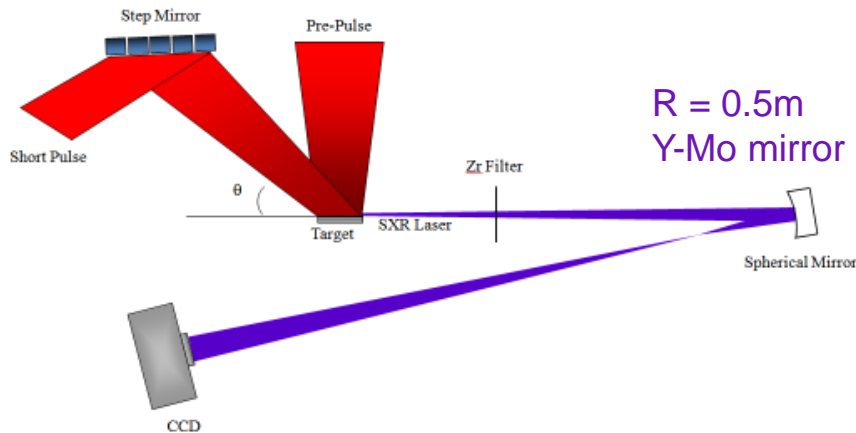
7.5 J Total Pump Energy

Pulse energy up to $\sim 2.7 \mu\text{J}$

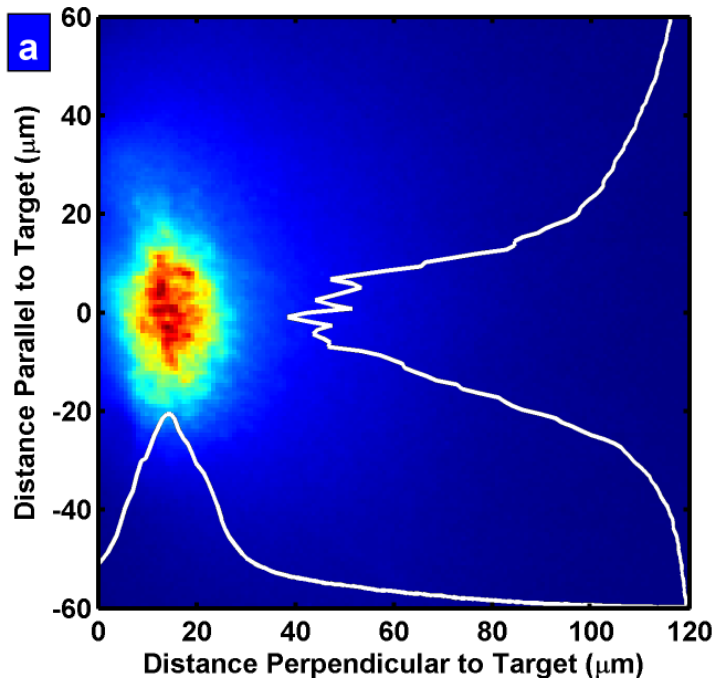
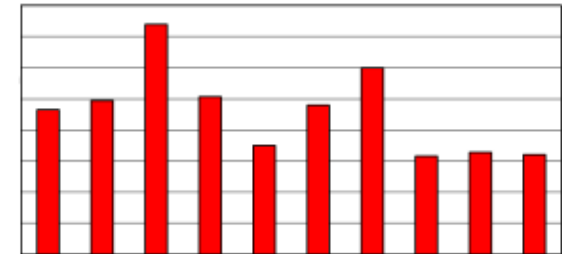


1 Hz $\lambda = 8.8$ nm laser output intensity exceeds computed saturation intensity by an order of magnitude

Near field beam profile measurement



1 Hz repetition rate

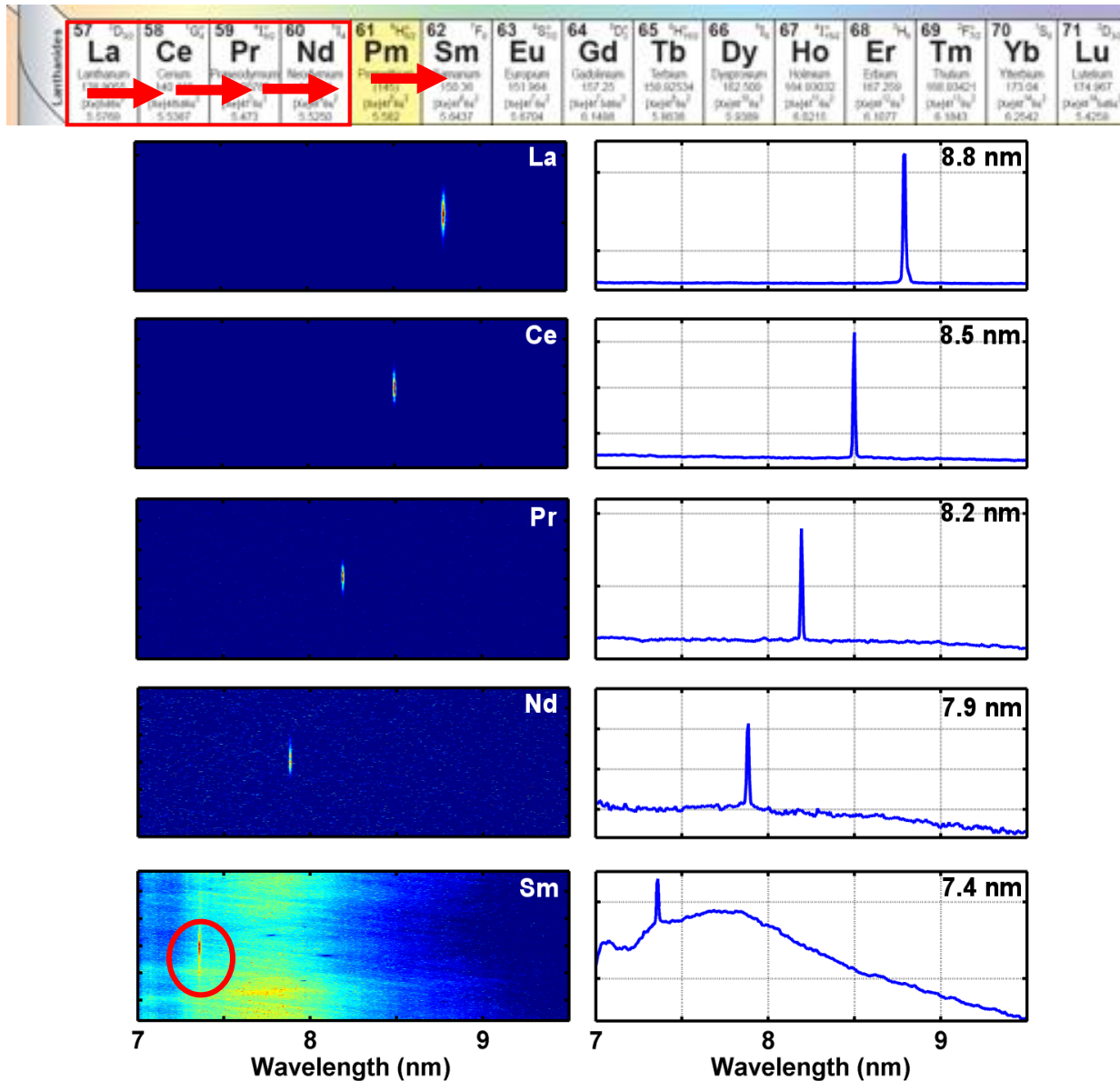


SXRL Fluence: 0.6 J cm^{-2}
 Experiment: $I \sim 2.4 \times 10^{11} \text{ W cm}^{-2}$
 Computed $I_{\text{sat}}: \sim 3 \times 10^{10} \text{ W cm}^{-2}$

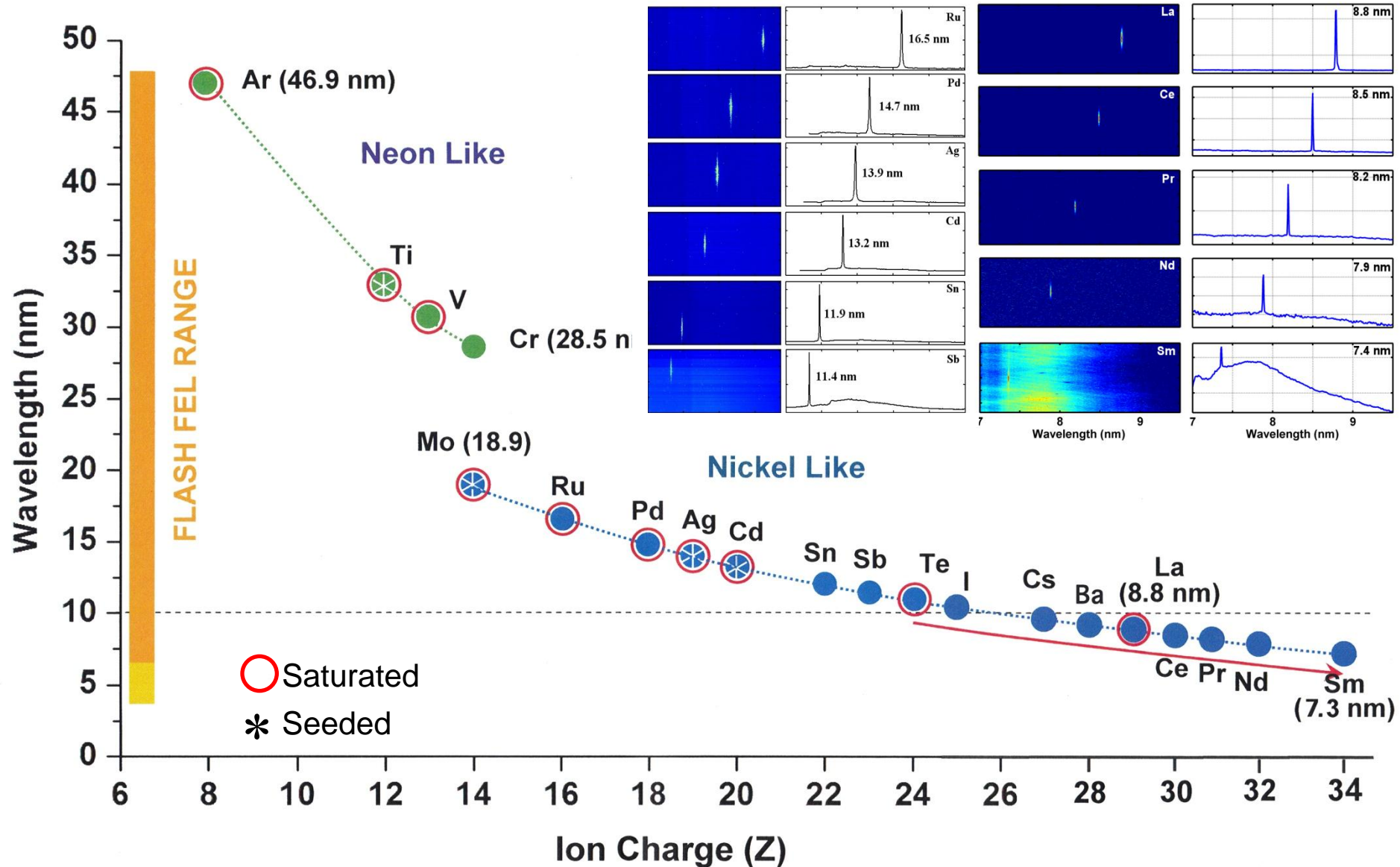
D. Alessi et al. Phys. Rev. X, 1, 021023 (2011)

Lasing in transitions down to 7.36 nm

Nickel-like lanthanide ions $4d^1S_0 - 4p^1P_1$



Gain-saturated table-top SXRLs cover 8.8 nm - 47 nm wavelength region

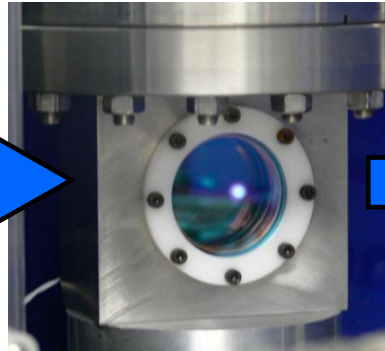


The Next Generation: Increasing the repetition rate of Table-Top Soft X-Ray Lasers to 100 Hz

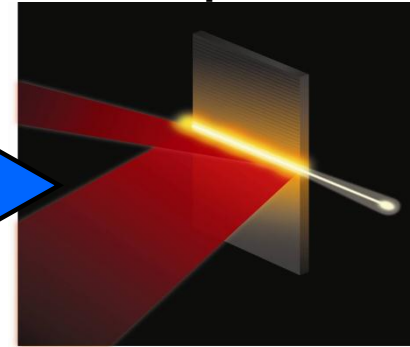
Laser Diode Drivers



Solid State Ultrashort Pulse High Power Laser



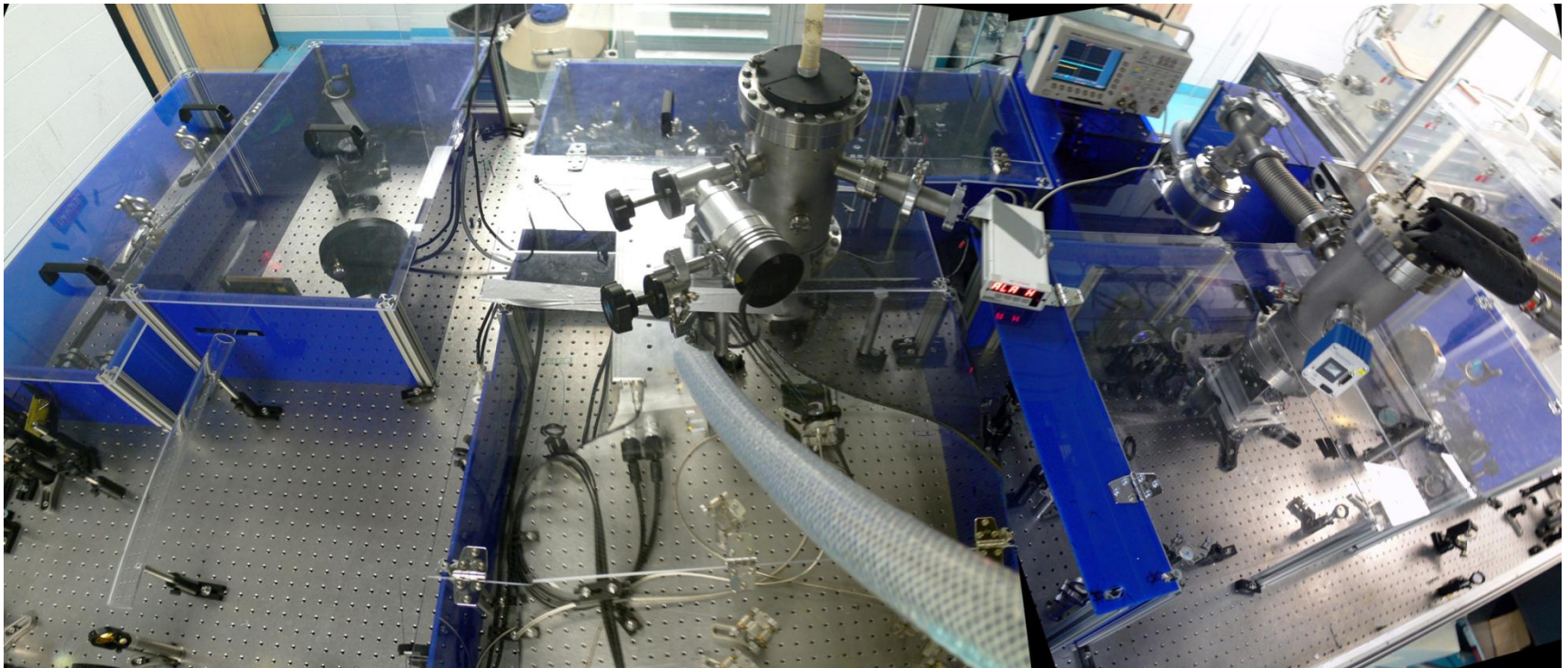
Soft X-Ray Plasma Amplifier



13.9 nm
laser

Ag^{+19}

e

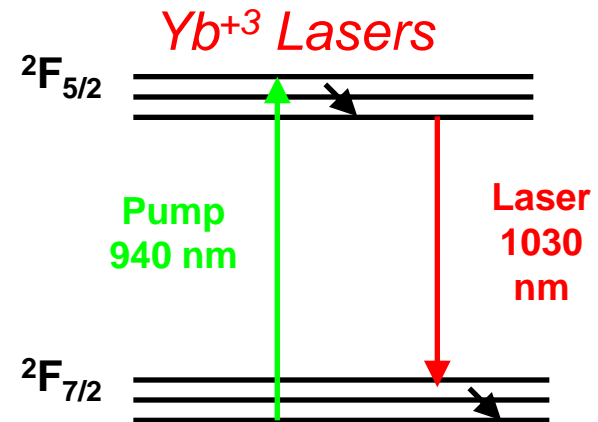


Directly diode-pumped Yb CPA laser increases repetition rate and average power

Laser Diode Pumping Advantages



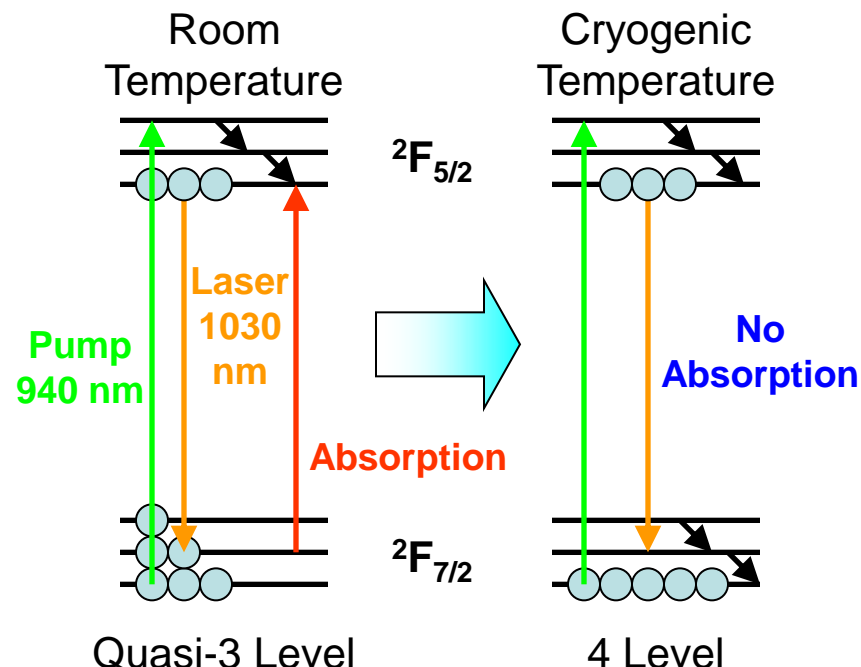
- Highly efficient
 - >50% Electrical efficiency
- Narrow bandwidth
 - Efficiently pump a single transition
- Directional
 - End-pumping
- Very high average power
 - Allow high repetition rate
- Compact



- Absorption bands at InGaAs wavelengths
- Very low quantum defect (<10%)
- Long lifetime for high energy storage

Thermal and gain properties of Yb:YAG are dramatically improved at cryogenic temperature

Yb:YAG at room and cryogenic temperature	300 K	77 K	
Thermal conductivity (W/mK)	10	90	x9
Thermo-optic coefficient ($10^{-6}/K$)	7.8	0.9	x1/7
Expansion coefficient ($10^{-6}/K$)	6.14	1.95	x1/4
Saturation fluence (J/cm^2)	9.2	1.7	x1/7

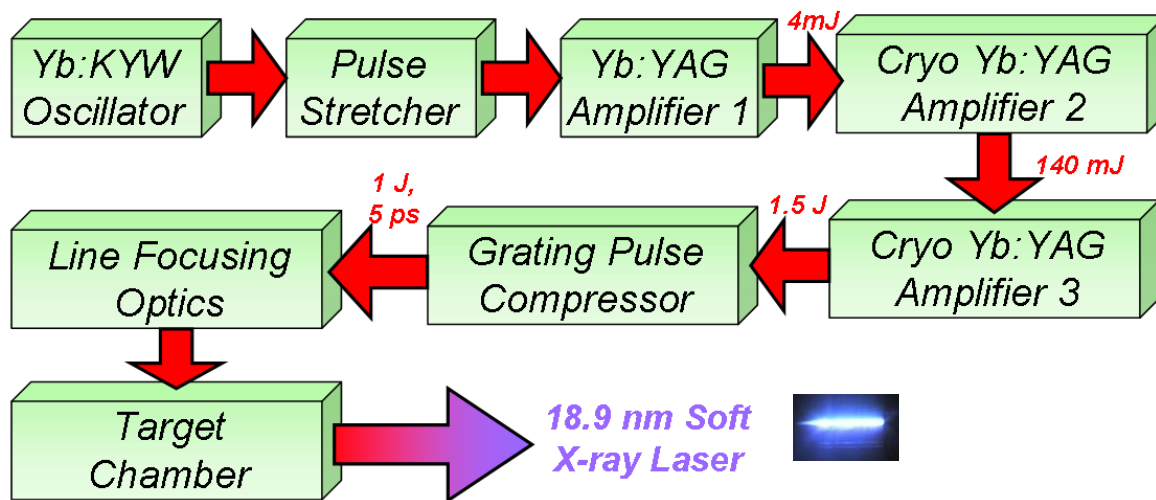


G. A Slack and D. W. Oliver; *Phys. Rev. B* **4**; 592-609 (1971)
 R. Wynne, J. L. Daneu and T. Y. Fan; *Appl. Opt.* **38**, 3282-3284 (1999)
 R.L. Aggarwal, et. al., *Journal of Applied Physics*, **98**, 103514, (2005).

Other recent cryogenic diode-pumped CPA work:

1. K.H. Hong, et al., *Optics Letters* **35**, 1752, (2010).
2. D. Rand, et al., CM3D.4 CLEO 2012.
3. D.E. Miller, et al., CM3D.2 CLEO 2012.
4. K. Ogawa, et al., CMB.4, CLEO 2011.

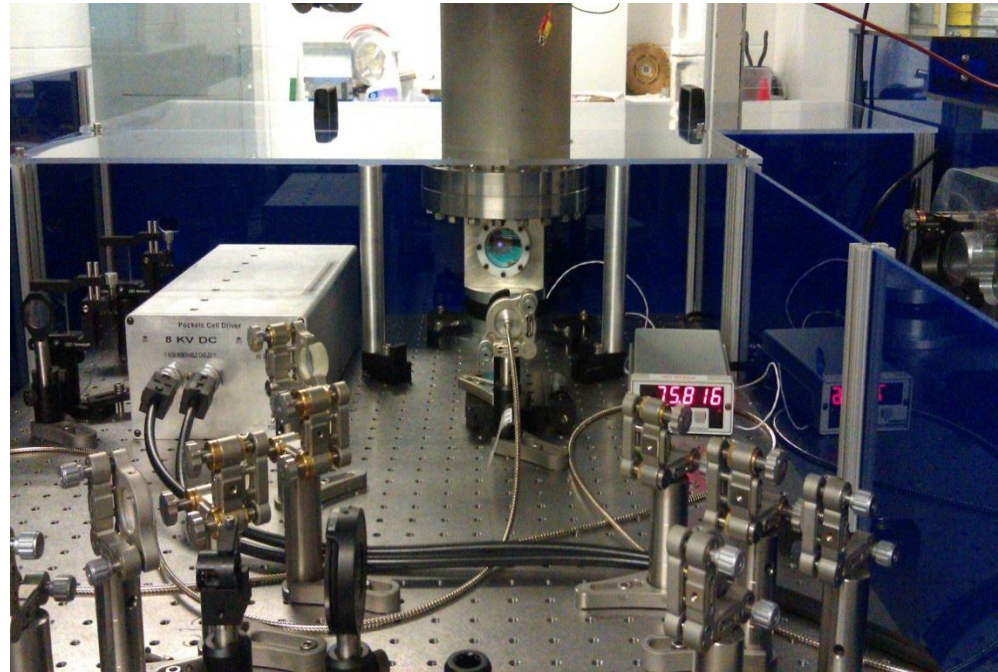
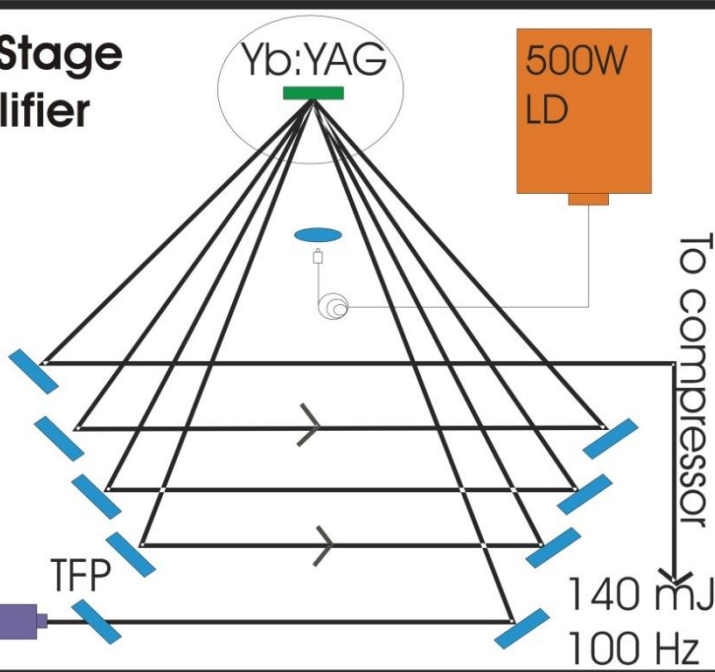
Compact high power diode-pumped CPA laser driver for 100 Hz table-top SXRL



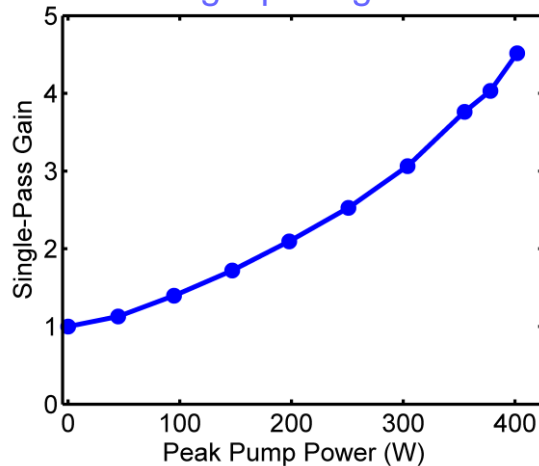
2nd stage cryo-cooled Yb:YAG amplifier

140 mJ, 100 Hz, amplifier operation demonstrated

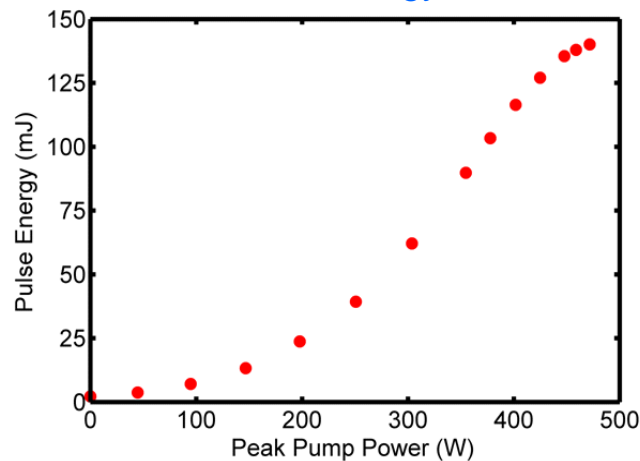
2nd Stage Amplifier



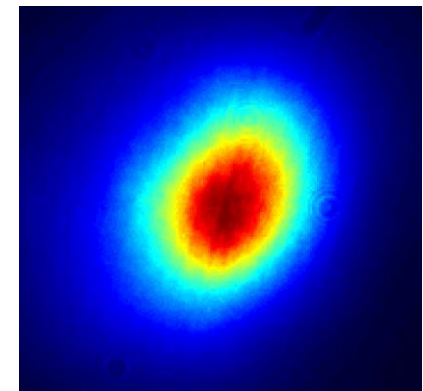
Single pass gain

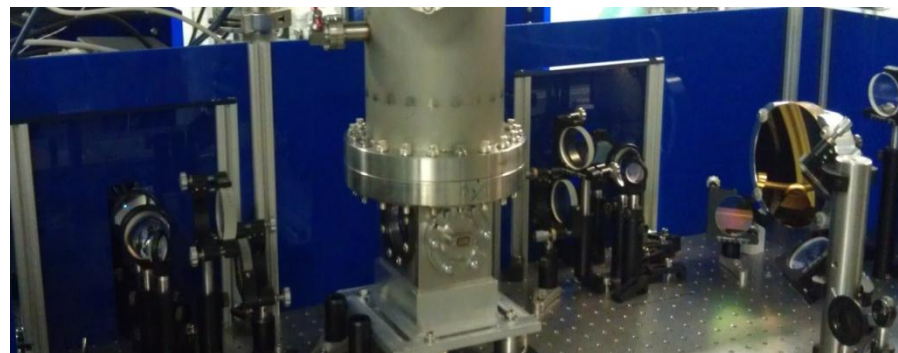
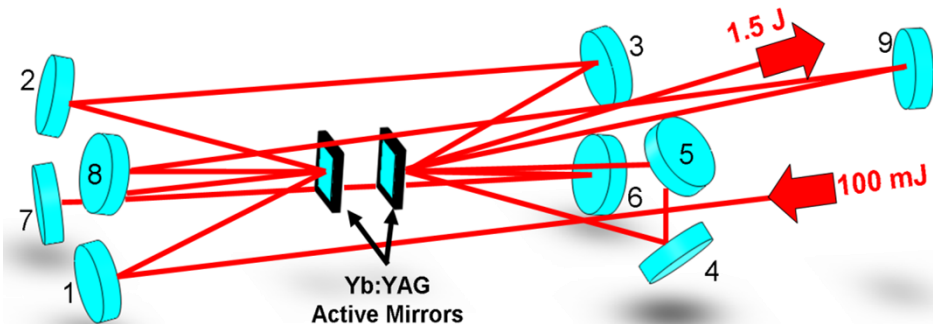


Pulse energy

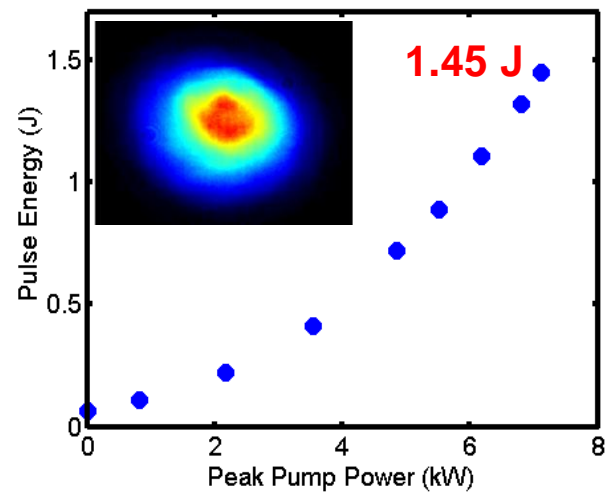


Beam pattern

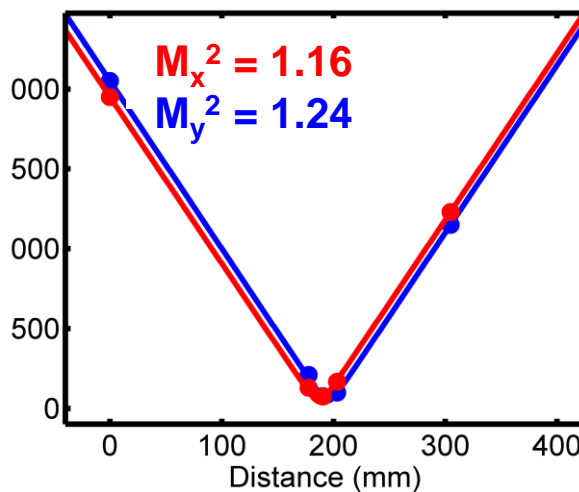




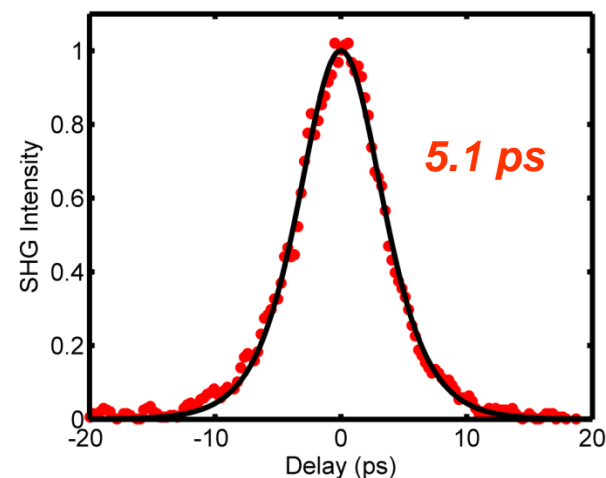
Uncompressed pulses



M^2 of amplified pulses

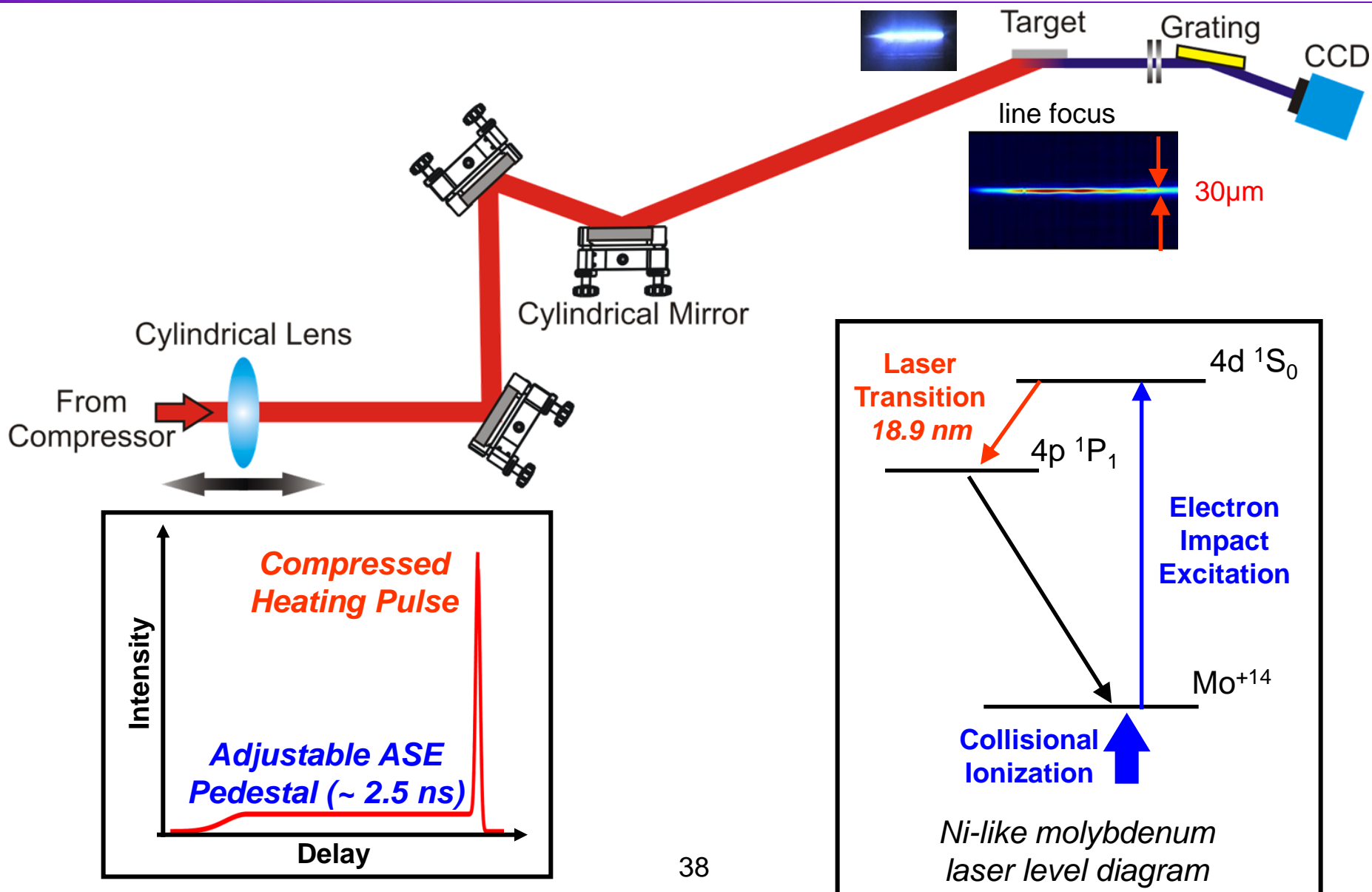


2nd order autocorrelation of compressed 1 J pulses

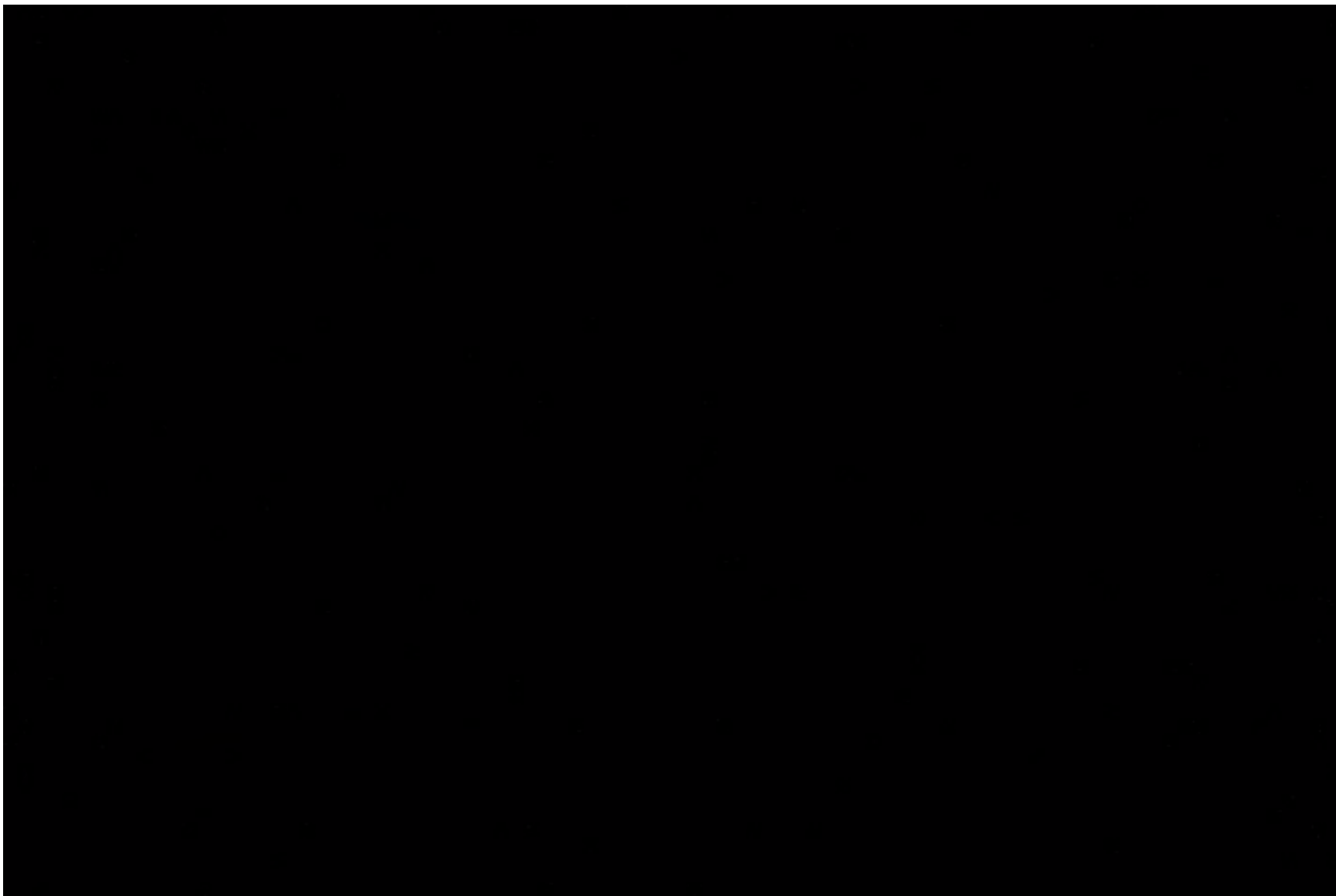


1 J, 5 ps pulses at 100 Hz repetition rate

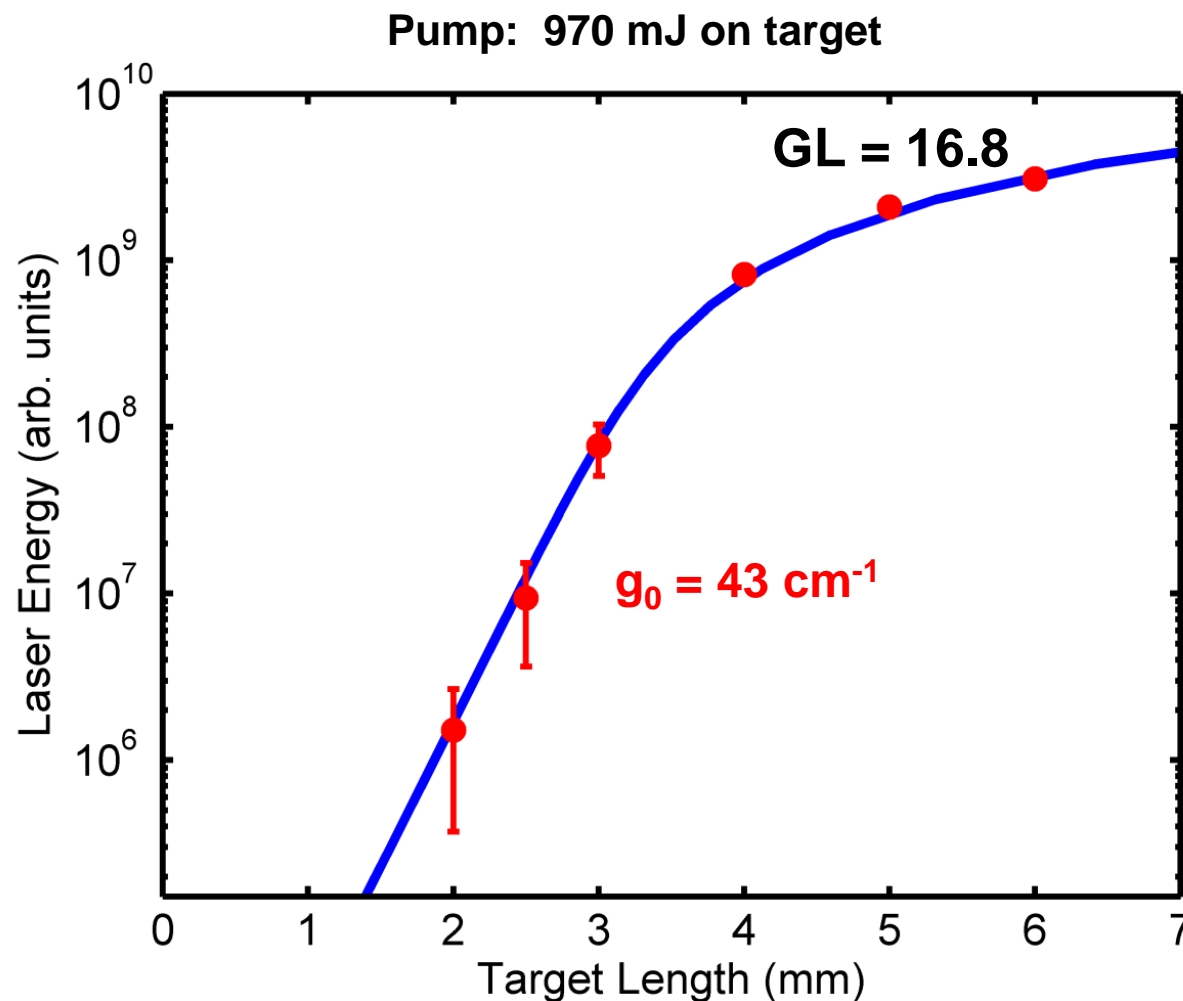
Soft X-Ray laser employs ns ASE pedestal followed by ps pump pulse from same CPA diode-pumped laser



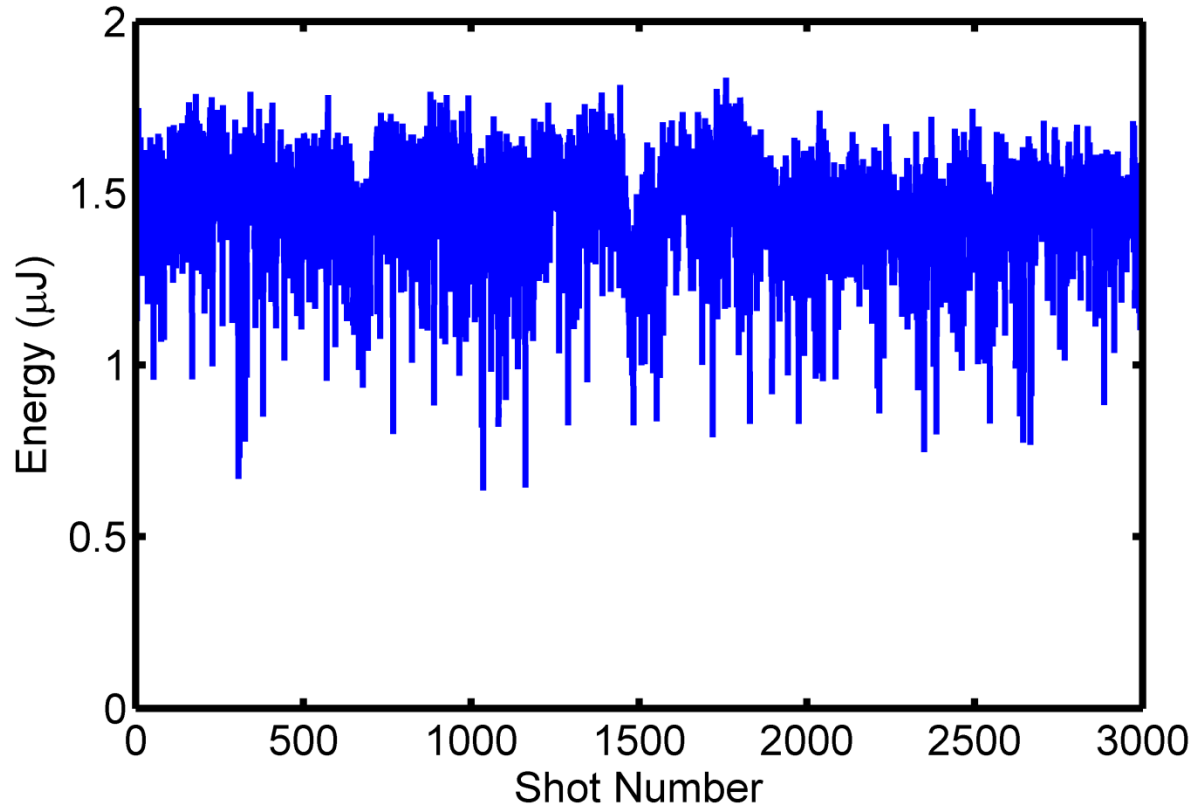
100 Hz Operation



Gain-Saturated 18.9nm Laser Operation at 100 Hz repetition rate



940 mJ on target target moved at 200 $\mu\text{m/s}$, (2 μm /shot)

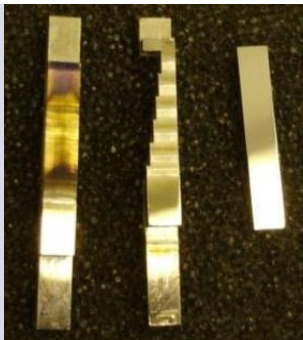


Mean Energy = 1.46 μJ , $\sigma = 11\%$

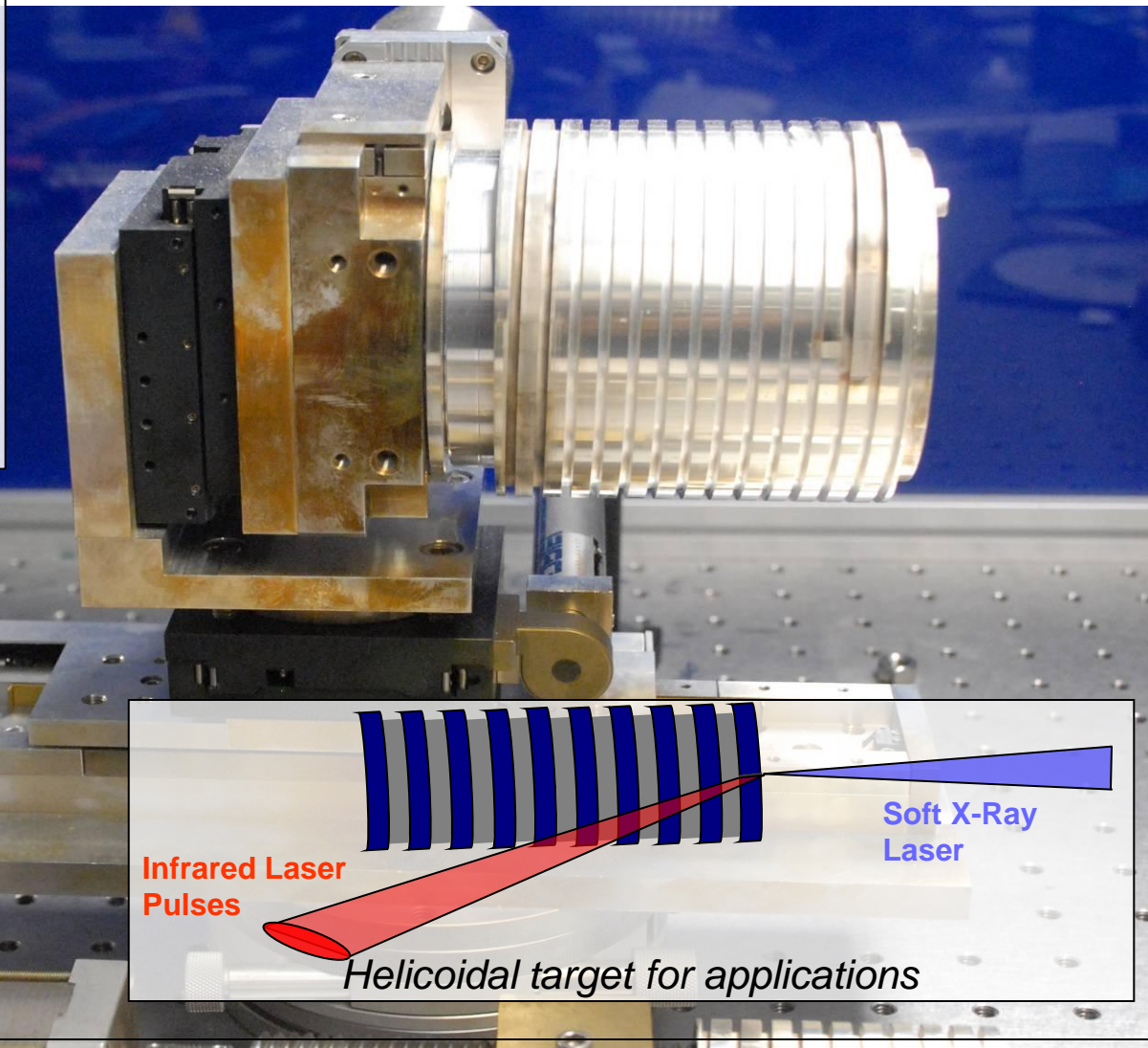
0.15 mW average power

(Fermi FEL 20-65 nm: 30-60 μJ x 10 Hz = 0.3-0.6 mW Luca Giannessi ICXRL)

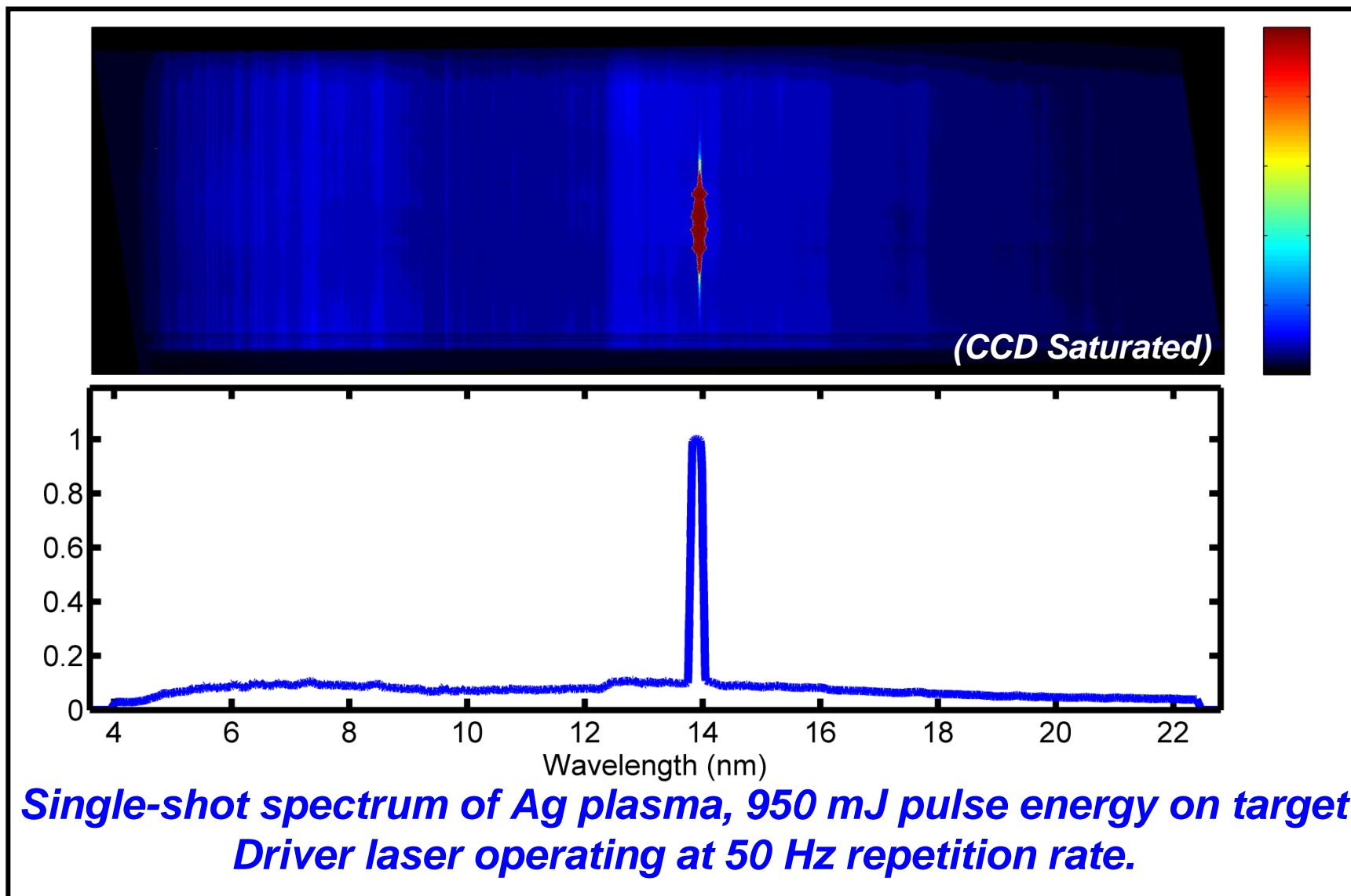
Helicoidal targets developed to allow continuous operation at 100 Hz repetition rate



Slab targets for parameterization of the soft x-ray laser

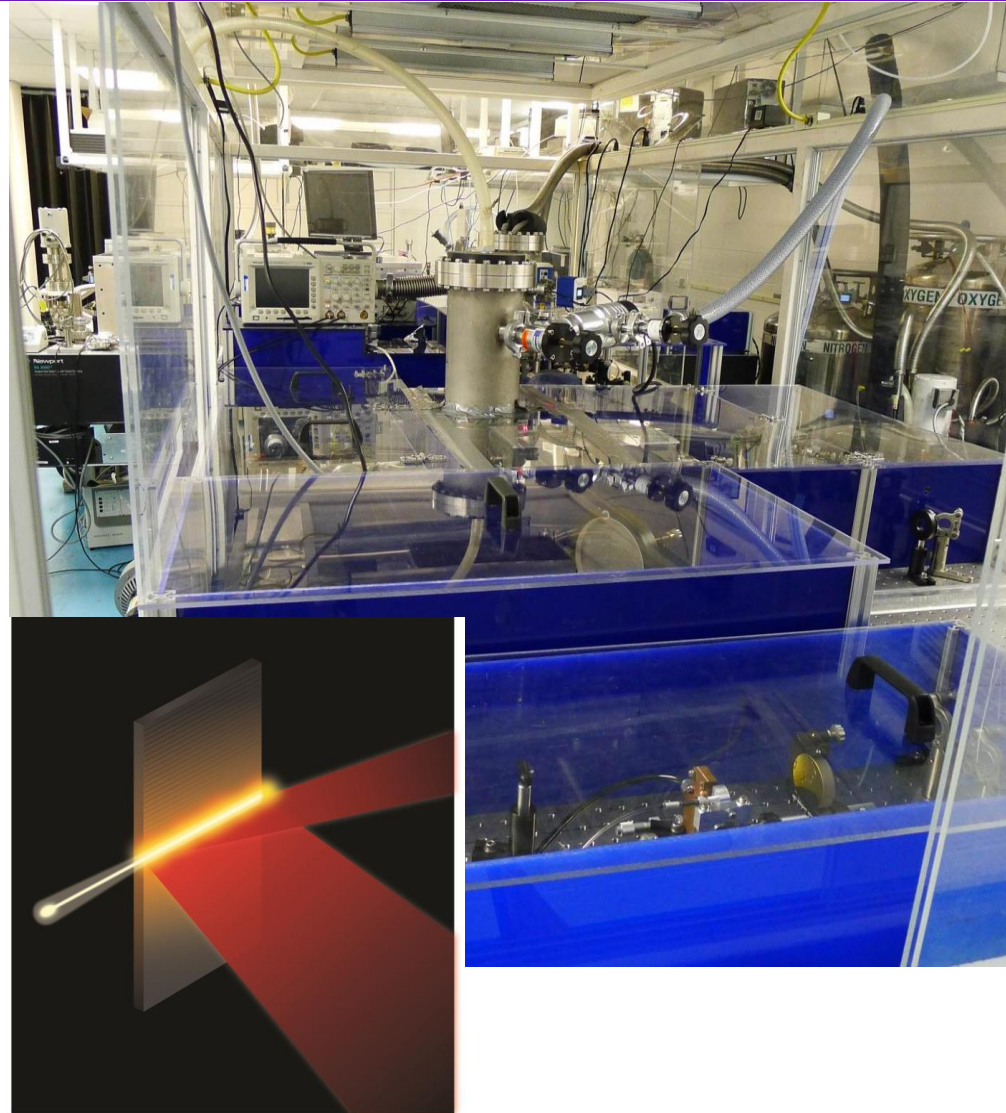


Demonstration of *all-diode-pumped laser* at 13.9nm in Ni-like silver plasma



Summary

- Gain-saturated table-top SXRLs reach $\lambda = 8.85$ nm. Amplification observed down to $\lambda = 7.3$
- Compact diode-pumped soft x-ray laser operating at record 100 Hz rep. rate produces 0.15 mW average power on a table-top



Work Supported by the NSF Engineering Research Centers Program
and the US Department of Energy

Acknowledgement

